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# Exhaustively Trichlorosilylated C<sub>1</sub> and C<sub>2</sub> Building Blocks: Beyond the Müller-Rochow Direct Process

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**ABSTRACT**: The Cl<sup>-</sup>-induced heterolysis of the Si–Si bond in Si<sub>2</sub>Cl<sub>6</sub> generates an [SiCl<sub>3</sub>]<sup>-</sup> ion as reactive intermediate. When carried out in the presence of CCl<sub>4</sub> or Cl<sub>2</sub>C=CCl<sub>2</sub> (CH<sub>2</sub>Cl<sub>2</sub> solutions, room temperature or below), the reaction furnishes the mono-carbanion [C(SiCl<sub>3</sub>)<sub>3</sub>]<sup>-</sup> ([**A**]<sup>-</sup>; 92%) or the vicinal dianion [(Cl<sub>3</sub>Si)<sub>2</sub>C–C(SiCl<sub>3</sub>)<sub>2</sub>]<sup>2<sup>-</sup></sup> ([**B**]<sup>2-</sup>; 85%) in excellent yields. Starting from [**B**]<sup>2-</sup>, the tetrasilylethane (Cl<sub>3</sub>Si)<sub>2</sub>(H)C–C(H)(SiCl<sub>3</sub>)<sub>2</sub> (H<sub>2</sub>**B**) and the tetrasilylethene (Cl<sub>3</sub>Si)<sub>2</sub>C=C(SiCl<sub>3</sub>)<sub>2</sub> (**B**; 96%) are readily available through protonation (CF<sub>3</sub>SO<sub>3</sub>H) or oxidation (CuCl<sub>2</sub>), respectively. Equimolar mixtures of H<sub>2</sub>**B**/[**B**]<sup>2-</sup> or **B**/[**B**]<sup>2-</sup> quantitatively produce 2 eq of the monoanion [H**B**]<sup>-</sup> or the blue radical anion [**B**<sup>-</sup>]<sup>-</sup>, respectively. Treatment of **B** with Cl<sup>-</sup> ions in the presence of CuCl<sub>2</sub> furnishes the disilylethyne Cl<sub>3</sub>SiC=CSiCl<sub>3</sub> (**C**; 80%); in the presence of [HMe<sub>3</sub>N]Cl, the trisilylethene (Cl<sub>3</sub>Si)<sub>2</sub>C=C(H)SiCl<sub>3</sub> (**D**; 72%) is obtained. Alkyne **C** undergoes a [4+2]-cycloaddition reaction with 2,3-dimethyl-1,3-butadiene (CH<sub>2</sub>Cl<sub>2</sub>, 50 °C, 3d) and thus provides access to 1,2-bis(trichlorosilyl)-4,5-dimethylbenzene (**E1**; 80%) after oxidation with DDQ. The corresponding 1,2-bis(trichlorosilyl)-3,4,5,6-tetraphenylbenzene (**E2**; 83%) was prepared from **C** and 2,3,4,5-tetraphenyl-2,4-cyclopentadien-1-one under CO extrusion at elevated temperatures (CH<sub>2</sub>Cl<sub>2</sub>, 180 °C, 4d). All closed-shell products were characterized by <sup>1</sup>H, <sup>13</sup>C {<sup>1</sup>H}, and <sup>29</sup>Si NMR spectroscopy; an EPR spectrum of [*n*Bu<sub>4</sub>N][**B**<sup>+</sup>] was recorded. The molecular structures of [*n*Bu<sub>4</sub>N][**A**], [*n*Bu<sub>4</sub>N]<sub>2</sub>[**B**], **B**, **E1**, and **E2** were further confirmed by single-crystal X-ray diffraction. Based on detailed experimental investigations, augmented by quantum-chemical calculations, plausible reaction mechanisms for the formation of [**A**]<sup>-</sup>, (**B**]<sup>2-</sup>, **C**, and **D** are postulated.

### INTRODUCTION

Functionalized organosilanes are versatile reagents for organic synthesis and indispensable building blocks for materials science. Their outstanding performance results from a number of unique electronic properties that distinguish silicon from its lighter group homologue carbon: (a) The lower electronegativity of Si  $(1.7)^{1}$ compared to C  $(2.5)^1$  renders the ionicity of an E–Si bond distinctly different from that of the corresponding E–C bond (E = chemical element). (b) Fragments C-SiR<sub>3</sub> carrying electron-releasing substituents R possess polarizable, energetically high-lying C-Si  $\sigma$  orbitals from which charge density can be transferred to properly aligned empty orbitals. A classic example for such hyperconjugation is seen in the stabilization of carbenium ions by geminal SiR<sub>3</sub> groups ( $\beta$ -silicon effect; Figure 1).<sup>2</sup> (c) Fragments E-SiX<sub>3</sub> carrying electronegative substituents X possess energetically accessible antibonding Si–X  $\sigma^*$  orbitals, which can accept electron density from  $\pi$ -donor atoms E, but also from external

Lewis bases L. The first type of interaction results in a partial  $E=SiX_3$  double-bond character and is also responsible for the marked C–H acidity at the  $\alpha$  position to a silyl group (E = C<sup>-</sup>). The second type facilitates the formation of five- and six-coordinate adducts (Figure 1).<sup>3</sup>



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Figure 1. Simplified orbital interactions underlying the β-silicon effect (left), the  $\alpha$ -silicon effect (middle), or dative L-Si  $\sigma$  interactions (right; L = Lewis base).

The aptitude of moieties C-SiX<sub>3</sub> to expand their coordination spheres and the more polarized C-Si bonds in adducts [C- $SiX_3L$ ]<sup>n-</sup> (n = 0, 1) are widely exploited in protecting group chemistry,<sup>4</sup> Tamao oxidations,<sup>5-10</sup> and Hiyama-type C–C-coupling reactions.<sup>11-17</sup> The Peterson olefination benefits from both the  $\alpha$  acidity and the Lewis acidity of alkylsilanes.<sup>18</sup> Common to all these examples is that the silvl groups do not appear in the final products, but are split off in the course of 10 the transformations. On the contrary, a number of important 11 functional materials are gaining their useful properties only 12 because the Si atoms remain as essential parts in the molecular 13 scaffolds. Examples are luminescent organosilanes, such as 14 hexaphenylsilole,<sup>19</sup> and silicones, the most abundant class of polymers with inorganic backbones.<sup>3</sup> Hyperconjugative 15 16  $n_0 \rightarrow \sigma_{SiX}^*$  interactions (cf. the  $\alpha$  effect) are primarily respon-17 sible for the increased torsional flexibility and diminished 18 basicity of silicones and thus contribute strongly to their broad application range.<sup>20</sup> Last but not least, organic trichlorosilyl 19 and trialkoxysilyl derivatives represent key starting materials 20 for the preparation of silsesquioxanes and other hybrid organ-21 ic-inorganic macromolecules, which find applications as sur-22 face coatings, catalyst supports, xerogels, ceramic precursors, and optoelectronic materials.  $^{\rm 21-28}$ 23 24

The Müller-Rochow Direct Process still constitutes the dominant technology for the preparation of organo(chloro)silanes on an industrial scale. At its most common level, the reaction involves CH<sub>3</sub>Cl and Si(Cu) as starting materials and gives (CH<sub>3</sub>)<sub>2</sub>SiCl<sub>2</sub> as the major product; the next most abundant species are CH<sub>3</sub>SiCl<sub>3</sub> and (CH<sub>3</sub>)<sub>3</sub>SiCl.<sup>3</sup> For the synthesis of more sophisticated (functionalized) organosilanes, Pt-catalyzed hydrosilylations of olefins and alkynes are extensively applied.<sup>29-33</sup> A third prominent synthesis approach relies on the transformation of SiCl<sub>4</sub> with organolithium or Grignard reagents.<sup>3</sup> However, this method has its limits in terms of functional-group tolerance and selectivity (e.g., multiple vs. single substitutions).<sup>34</sup> Problems also occur in the case of multiply silvlated compounds, because the required multiply metallated organic intermediates are often hard to obtain, extremely sensitive, and poorly soluble.35,36 Alternatively, a polarity-inverted pathway starting from organic halides and nucleophilic silanides is conceivable.

The only systematically investigated silanide-related systems for the preparation of organo(chloro)silanes currently remain the HSiCl<sub>3</sub>/NR<sub>3</sub> combination ('Benkeser reagent'; NR<sub>3</sub> = tertiary amine, typically  $N(nPr)_3$  or  $N(nBu)_3$ , in stoichiometric amounts) and the HSiCl<sub>3</sub>/ $[R_4P]Cl$  pair  $([R_4P]^+ = quater$ nary phosphonium salt, typically  $[nBu_4P]^+$ , in catalytic amounts). The Benkeser reagent<sup>37</sup> has been employed to produce organotrichlorosilanes through reductions of carboxyl or carbonyl derivatives,<sup>38-41</sup> hydrosilylations of alkenes or al-kynes,<sup>42-44</sup> and the silylation of alkyl halides.<sup>45,46</sup> With respect to the latter transformation, it is important to note that nonactivated alkyl halides fail to yield the respective alkyl trichlorosilanes. Suitable substrates are benzyl and allyl halides as well as geminal polyhalogenated hydrocarbons. Thus, mesomeric or inductive electron withdrawal from the reaction center and the efficient stabilization of putative carbanionic

intermediates seem to be prerequisites for a successful halo-gen/SiCl<sub>3</sub> exchange.  $^{37,45,46}$  The limitation of the Benkeser reagent to activated alkyl halide starting materials can partly be overcome by employing the HSiCl<sub>3</sub>/[R<sub>4</sub>P]Cl pair, which allows trichlorosilylations also of simple primary alkyl chlorides.47,48 In terms of the reaction mechanism, already Benkeser postulated the initial formation of [SiCl<sub>3</sub>]<sup>-</sup>/[HR<sub>3</sub>N]<sup>+</sup> ion pairs.<sup>37,49</sup> Depending on the reaction conditions, the chimeric [SiCl<sub>3</sub>]<sup>-</sup> ion behaves either as a silanide nucleophile or as a dichlorosilvlene source: i.e.,  $[SiCl_3]^{-}/[HR_3N]^{+}$  vs. [SiCl<sub>2</sub>]/[HR<sub>3</sub>N]Cl.<sup>50-53</sup> Thus, both nucleophilic pathways and silvlene insertion channels have to be regarded as plausible reaction scenarios. Recently, the Si<sub>2</sub>Cl<sub>6</sub>/[R<sub>4</sub>E]Cl combination has been identified as an alternative source of [SiCl<sub>3</sub>]<sup>-</sup> ions (E = N, P; R = Et, *n*-Bu, Ph):<sup>54</sup> Nucleophilic attack of chloride on the disilane results in the heterolytic cleavage of the Si-Si bond with concomitant formation of  $SiCl_4$  and  $[SiCl_3]^-$  (Scheme 1).<sup>55,56</sup> In the presence of residual  $Si_2Cl_6$ , the thereby liberated [SiCl<sub>3</sub>]<sup>-</sup> induces the assembly of oligosilane scaffolds, such as perchlorinated cyclohexasilanes or  $Si_{20}$  dodecahedranes ('silafulleranes').<sup>55,57,58</sup>

Scheme 1. Generation of [SiCl<sub>3</sub>]<sup>-</sup> and/or [SiCl<sub>2</sub>] from Si<sub>2</sub>Cl<sub>6</sub> in the presence of chloride ions.



Herein, we are expanding the reaction scope of the Si<sub>2</sub>Cl<sub>6</sub>/[*n*Bu<sub>4</sub>N]Cl combination to the synthesis of key organosilane reagents via convenient one-pot protocols ( $[A]^{-}$  E; Figure 2). The monoanion  $[A]^-$  and vicinal dianion  $[B]^{2-}$  are archetypal examples of the stabilizing effect of silvl groups on  $\alpha$  carbanions. Moreover, potentially nucleophilic sites coexist with strongly electrophilic sites. Compounds HA and  $H_2B$ , the conjugate acids of  $[A]^-$  and  $[B]^{2-}$ , are potentially relevant to the preparation of organic-inorganic hybrid materials such as silsesquioxanes and xerogels. The electron-poor unsaturated derivatives **B**, **C**, and **D** should readily undergo substitution reactions at the Si atoms and/or cycloaddition reactions at the unsaturated organic backbones. This provides a broad range of oligo-functionalized precursors to be employed in, e.g., Hiyama-type C-C-coupling protocols (cf. E).<sup>59-6</sup>



Figure 2. Target compounds of this work: the persilylated monocarbanion  $[A]^-$ , the dicarbanion  $[B]^{2-}$ , and their corresponding acids HA/H<sub>2</sub>B; the (per)silylated ethenes B/D, ethyne C, and benzenes E.

### **RESULTS AND DISCUSSION**

Some of the target compounds compiled in Figure 2 have previously been mentioned in the literature. However, as will be shown below, most of the respective synthesis protocols are at best inconvenient and at worst not practical on a laboratory scale.

In the following, we will first provide a brief literature survey on compounds  $[A]^- E$ . Second, we will disclose efficient means to prepare the anions  $[A]^-$  and  $[B]^{2-}$  and show that all the other target compounds are readily accessible from these two starting materials. Analytical details and reactivity patterns of  $[A]^- E$  will be discussed in the third section. The final paragraph of this publication is devoted to mechanistic considerations.

### Previous Mentions of [A] – E.

We first observed the tris(trichlorosilyl)methanide salt  $[nBu_4N][A]$  in the thermolysate of  $[nBu_4N]_2[1,1-(Cl_3Si)_2Si_6Cl_{10} \cdot 2Cl]$ , the chloride diadduct of the substituted cyclohexasilane 1,1-(Cl\_3Si)\_2Si\_6Cl\_{10} (CH\_2Cl\_2, 85 °C; Scheme 2).<sup>55,62</sup> Under the conditions applied, stripping of both SiCl\_3 substituents occurred to give the diadduct  $[nBu_4N]_2[Si_6Cl_{12} \cdot 2Cl]$  of parent Si\_6Cl\_2.

### Scheme 2. Thermolysis of $[nBu_4N]_2[1,1-(Cl_3Si)_2Si_6Cl_{10}\cdot 2Cl]$ in $CH_2Cl_2$ to furnish $[nBu_4N]_2[Si_6Cl_{12}\cdot 2Cl]$ and $[nBu_4N][A]$ as part of a complex product mixture.



Cation =  $[nBu_4N]^+$  omitted for clarity. (i) CH<sub>2</sub>Cl<sub>2</sub>, 85 °C in a sealed vial, 4 h.

Dichlorosilylenes, formally liberated in the course of the stripping reaction, are found re-inserted into C–Cl and C–H bonds of the solvent, thereby ultimately furnishing  $[nBu_4N][A]$  and H<sub>2</sub>C(SiCl<sub>3</sub>)<sub>2</sub>, which was detected as a side product. When Kroke et al. reproduced the synthesis of  $[nBu_4N]_2[Si_6Cl_{12} \cdot 2Cl]$ , they succeeded in the isolation of  $[nBu_4N][A]$  with 17% yield (Scheme 3, top); they also mentioned that  $[nBu_4N][A]$  was formed from a mixture of Si<sub>2</sub>Cl<sub>6</sub>/[ $nBu_4N$ ][A] in CHCl<sub>3</sub> (no yield given).<sup>63</sup> In contrast to  $[nBu_4N][A]$ , its dianionic homologue  $[nBu_4N]_2[B]$  remained elusive until to-date.

Corriu et al. synthesized preparatively useful amounts of HA by treatment of CHCl<sub>3</sub> with excess Benkeser reagent. The chlorosilane HA was not isolated, but routinely transformed to HC(Si(OEt)<sub>3</sub>)<sub>3</sub> via ethanolysis (30%; Scheme 3, top).<sup>27,64</sup> Some tetrasilylethane H<sub>2</sub>B forms upon reaction of Cl(H)C(SiCl<sub>3</sub>)<sub>2</sub> with Si(Cu) at 300-320 °C in a fixed bed reactor; the synthesis of the precursor molecule, Cl(H)C(SiCl<sub>3</sub>)<sub>2</sub>, requires gas-phase

photochlorination of H<sub>2</sub>C(SiCl<sub>3</sub>)<sub>2</sub> (Scheme 3).<sup>65</sup> The corresponding alkene, (Cl<sub>3</sub>Si)<sub>2</sub>C=C(SiCl<sub>3</sub>)<sub>2</sub> (**B**), and alkyne, Cl<sub>3</sub>SiC=CSiCl<sub>3</sub> (**C**), are accessible through dechlorinative coupling of Cl<sub>2</sub>C(SiCl<sub>3</sub>)<sub>2</sub> with Cu metal in a stirred bed reactor as parts of a multi-component mixture (Scheme 3, bottom).<sup>66,67</sup> Alternatively, CCl<sub>4</sub> gives some **C** (18%) in the Müller-Rochow Direct Process.<sup>66,68</sup> Catalytic hydrosilylation of **C** has been employed to prepare the 1,1,2-trisilylethene **D** (88%).<sup>69</sup>





The cation =  $[nBu_4N]^+$  is omitted for clarity. The yields of H<sub>2</sub>**B**, **B**, and C refer to H<sub>2</sub>C(SiCl<sub>3</sub>)<sub>2</sub>. (i) CH<sub>2</sub>Cl<sub>2</sub>, 85 °C in a sealed vial, 24 h; (ii) CH<sub>3</sub>CN, -40 °C to 65 °C, 16 h; (iii) gas phase, highpressure Hg lamp, 30 h; (iv) Si(Cu), 300-320 °C in a fixed bed reactor, 16 h; (v) CCl<sub>4</sub>, reflux temperature, 64 h; (vi) Cu, room temperature to 380 °C, 2.5 h. (vii) Speier catalyst in *i*PrOH, 90 °C, sealed glass ampoule, 6 d.

### Syntheses of $[nBu_{k}N][A] - E$ .

We first revisited and expanded the previous studies by our and Kroke's group and systematically screened the behavior of Si<sub>2</sub>Cl<sub>6</sub>/[*n*Bu<sub>4</sub>N]Cl toward the entire series of chloromethanes. In brief, C–Si coupling took place with all four substrate molecules: From a solution of CH<sub>3</sub>Cl in CH<sub>2</sub>Cl<sub>2</sub>, we obtained CH<sub>3</sub>SiCl<sub>3</sub>. CH<sub>2</sub>Cl<sub>2</sub> and CHCl<sub>3</sub>, employed both as reagents and solvents, furnished [*n*Bu<sub>4</sub>N][**A**] in yields of 34% (sealed glass ampoule, 120 °C, 30 h) and 78% (reflux temperature, 2 h), respectively (cf. the SI for more details). Almost quantitative yields of [*n*Bu<sub>4</sub>N][**A**] were harvested from 4:1:1.5 mixtures of Si<sub>2</sub>Cl<sub>6</sub>, [*n*Bu<sub>4</sub>N]Cl, and CCl<sub>4</sub> in CH<sub>2</sub>Cl<sub>2</sub> (Scheme 4, top).<sup>70</sup> This new protocol opens a time- and cost-efficient access route to

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preparatively useful quantities of  $[nBu_4N][A]$ , it does not require elevated temperatures, the exothermic reaction occurs instantaneously, and workup is facile.

Scheme 4. Reactions of CCl<sub>4</sub> and C<sub>2</sub>Cl<sub>4</sub> with Si<sub>2</sub>Cl<sub>6</sub>/[*n*Bu<sub>4</sub>N]Cl, resulting in the formation of C-Sibonded species. н SiCl<sub>3</sub> 1.5 CCI4 1 Cl CE<sub>2</sub>SO<sub>2</sub>F "'<mark>S</mark>iR<sub>3</sub> SiR<sub>3</sub> SiCl (i) or MeOH 4 Si<sub>2</sub>Cl<sub>6</sub> [nBu<sub>4</sub>N][A] R= CI: HA 92% or R= OMe: HAOMe 59% 0.05 CI x 2, + Cl Cl<sub>3</sub>C-SiCl<sub>3</sub> - SiCl<sub>4</sub> (ii) 37% (iv) CCI4 C Cl<sub>3</sub>C-96% 1 Si<sub>2</sub>Cl<sub>6</sub> C x 2 SiCl4, Cl CI C (iv)SiR<sub>3</sub> Cl<sub>3</sub>Si SiCl<sub>3</sub> 1 C<sub>2</sub>Cl<sub>4</sub> 2 CI CF<sub>3</sub>SO<sub>3</sub>H SiR3 ΘC CO R<sub>3</sub>Si CH<sub>2</sub>Cl<sub>2</sub> or MeOH SiCl<sub>3</sub> H 4 Si<sub>2</sub>Cl<sub>6</sub> Cl<sub>3</sub>Si R<sub>3</sub>Si (v) [nBu<sub>4</sub>N]<sub>2</sub>[B] R= CI: H<sub>2</sub>B or R= OMe: H2BOMe 85% 88% SiCl  $1 H_2 B$ CΘ SiCl<sub>3</sub> Cl<sub>3</sub>Si [nBu<sub>4</sub>N][HB]

The cation =  $[nBu_4N]^+$  is omitted for clarity. Synthesis of HA/HAOMe or H<sub>2</sub>**B**/H<sub>2</sub>**B**OMe via protonation/methanolysis of  $[nBu_4N][A]$  or  $[nBu_4N]_2[B]$ ; synthesis of  $[nBu_4N][HB]$  through proton transfer between H<sub>2</sub>**B** and  $[nBu_4N]_2[B]$ . (i) CH<sub>2</sub>Cl<sub>2</sub>, 0 °C to room temperature, 1 h; (ii) CCl<sub>4</sub>, room temperature, 24 h; (iii) CCl<sub>4</sub>, room temperature, 1 h; (iv) CH<sub>2</sub>Cl<sub>2</sub>, room temperature, 1 h; (v) CH<sub>2</sub>Cl<sub>2</sub>, -10 °C to room temperature, 12 h.

CCl<sub>4</sub> possesses the highest reactivity among the four chloromethanes. Competing solvent activation does therefore not occur even under conditions of high dilution, which is of crucial importance in the present context: Contrary to the cases of  $CH_2Cl_2$  and  $CHCl_3$ , no  $[nBu_4N][A]$  formed when  $Si_2Cl_6$  was added to  $[nBu_4N]Cl$  in excess neat  $CCl_4$  (Scheme 4, middle). Depending on the relative amounts of the chloride salt, we either obtained the perchlorinated methylsilane  $Cl_3C$ -SiCl<sub>3</sub> (catalytic [*n*Bu<sub>4</sub>N]Cl; 95% conversion, 37% yield) or its  $[CCl_3]^-$  adduct  $[nBu_4N][Cl_3C-SiCl_3-CCl_3]$  after recrystallization from CH<sub>2</sub>Cl<sub>2</sub> (1 eq [*n*Bu<sub>4</sub>N]Cl, 96% yield; relative to Si<sub>2</sub>Cl<sub>6</sub>). Cl<sub>3</sub>C-SiCl<sub>3</sub> is usually prepared via the potentially hazardous photochlorination of H<sub>3</sub>C-SiCl<sub>3</sub>,<sup>6</sup> whereas  $[nBu_4N][Cl_3C-SiCl_3-CCl_3]$  is so far unknown. Our current working hypothesis assumes that a primary Cl<sup>-</sup> adduct  $[nBu_4N]$ [Cl<sub>3</sub>C–SiCl<sub>4</sub>] acts as a Cl<sub>3</sub>C-transfer reagent along the way from  $Cl_3C$ -SiCl<sub>3</sub> to  $[nBu_4N][Cl_3C$ -SiCl<sub>3</sub>-CCl<sub>3</sub>]. In the

non-polar solvent CCl<sub>4</sub>, the ionic species  $[nBu_4N][Cl_3C-SiCl_4]$ and  $[nBu_4N][Cl_3C-SiCl_3-CCl_3]$  precipitate immediately and can thus no longer participate in further reactions. The chemical constitution of  $[nBu_4N][Cl_3C-SiCl_4]$  was confirmed by Xray crystallography, however, the poor crystal quality precludes publication of the data (cf. the SI for more information). We finally emphasize a conceptual relationship between  $[Cl_3C-SiCl_3-CCl_3]^-$  and the previously published anion  $[Cl_3Si-SiCl_3-SiCl_3]^-$ , which has been interpreted as the  $[SiCl_3]^-$  adduct of Si<sub>2</sub>Cl<sub>6</sub>.<sup>55,62</sup>

The fact that the reaction of CCl<sub>4</sub> with Si<sub>2</sub>Cl<sub>6</sub>/[nBu<sub>4</sub>N]Cl made three important organosilane building blocks readily available, prompted us to study next the synthetic potential of the higher homologue C<sub>2</sub>Cl<sub>6</sub>. Treatment of this compound with 1 eq of  $Si_2Cl_6$  and catalytic amounts of  $[nBu_4N]Cl$  at room temperature in CD<sub>2</sub>Cl<sub>2</sub> led to clean dechlorination with formation of tetrachloroethene (C<sub>2</sub>Cl<sub>4</sub>; see the SI for more details and Ref[37] for a related transformation). C<sub>2</sub>Cl<sub>4</sub> was therefore employed as starting material in all further reactions with  $Si_2Cl_6/[nBu_4N]Cl$  (Scheme 4, bottom), which always furnished at least some  $[nBu_4N]_2[\mathbf{B}]$ , irrespective of the stoichiometric ratios employed. The optimized protocol for the synthesis of  $[nBu_4N]_2[\mathbf{B}]$  requires Si<sub>2</sub>Cl<sub>6</sub> (4 eq), which is added at -10 °C to a solution of [nBu<sub>4</sub>N]Cl (2 eq) and C<sub>2</sub>Cl<sub>4</sub> (1 eq) in CH<sub>2</sub>Cl<sub>2</sub>. After warming to room temperature, colorless crystals of  $[nBu_4N]_2[\mathbf{B}]$  can be isolated from the deep blue reaction mixture in yields of 85%.

As first reactivity tests, we treated  $[nBu_4N][A]$  and  $[nBu_4N]_2[B]$  with anhydrous MeOH/NMe<sub>2</sub>Et and obtained HAOMe<sup>64</sup> and H<sub>2</sub>BOMe in yields of 59% and 88%, respectively. By the same token, protonation with CF<sub>3</sub>SO<sub>3</sub>H selectively furnished HA<sup>71</sup> and H<sub>2</sub>B,<sup>65</sup> respectively. Both protonation reactions can also be conducted with ethereal HCl, but care must be taken to avoid partial desilylation by nucleophilic attack of Cl<sup>-</sup>. The monoprotonated species  $[nBu_4N][HB]$  is accessible by adjusting the amount of acid employed or by simple mixing of  $[nBu_4N]_2[B]$  and H<sub>2</sub>B in equimolar quantities (Scheme 4, bottom).

Equimolar mixtures of  $[nBu_4N]_2[\mathbf{B}]$  and  $\mathbf{B}$  undergo a comproportionation reaction to furnish the blue-colored monoradical  $[nBu_4N][\mathbf{B}']$ . The two-electron oxidation of  $[nBu_4N]_2[\mathbf{B}]$  was carried out with 2 eq of CuCl<sub>2</sub> under heterogeneous conditions and affords the tetrasilylethene  $\mathbf{B}$  in yields of 96% (Scheme 5).

The targeted cleavage of C–Si bonds by halide ions (mainly  $F^-$  and  $C\Gamma$ ) is broadly exploited in organic synthesis, particularly in protecting group chemistry.<sup>4</sup> We now found that **B** formally eliminates Si<sub>2</sub>Cl<sub>6</sub> upon addition of [*n*Bu<sub>4</sub>N]Cl (1 eq) to provide the bis(trichlorosilyl)ethyne **C** (Scheme 5). During workup, **C** (41%) was separated from the byproduct [*n*Bu<sub>4</sub>N]<sub>2</sub>[**B**] (43%) through extraction into *n*-pentane. Based on the observation that the byproduct [*n*Bu<sub>4</sub>N]<sub>2</sub>[**B**] can be recycled through *in situ* oxidation with CuCl<sub>2</sub>, we developed an optimized one-pot protocol to prepare **C** from Si<sub>2</sub>Cl<sub>6</sub> (4 eq), [*n*Bu<sub>4</sub>N]Cl (4 eq), C<sub>2</sub>Cl<sub>4</sub> (1 eq), and CuCl<sub>2</sub> (4 eq) in a yield of 80%. The alkyne content of the *n*-pentane stock solution was determined by quenching an aliquot with MeOH and titration of the produced HCl. Even though fractional distillation of the extract affords **C** as a colorless oil, the effort is lowered and

yield losses are avoided, if the *n*-pentane extract is used directly for further transformations.

Scheme 5: Transformations of  $[nBu_4N]_2[B]$  to give  $H_2B$ ,  $[nBu_4N][B']$ , B, or C.



The cation =  $[nBu_4N]^+$  is omitted for clarity. (i) CD<sub>2</sub>Cl<sub>2</sub>, room temperature, 1 h; (ii) C<sub>6</sub>D<sub>6</sub>, 120-150 °C in a sealed NMR tube, 8 d; (iii) 2 eq CuCl<sub>2</sub>, CH<sub>2</sub>Cl<sub>2</sub>, room temperature, 1 h; (iv) 1 eq [HMe<sub>3</sub>N]Cl, 10 mol% [*n*Bu<sub>4</sub>N]Cl, CH<sub>2</sub>Cl<sub>2</sub>, room temperature, 3 d.

A mono-desilylation of **B** to afford the 1,1,2tris(trichlorosilyl)ethene **D** (72%) is achievable at room temperature in CH<sub>2</sub>Cl<sub>2</sub> using [HMe<sub>3</sub>N]Cl (1 eq) as a mild H<sup>+</sup> source and a catalytic amount of  $[nBu_4N]Cl$ .<sup>72</sup>

The unsaturated compounds **B**–**D** constitute highly promising reagents for the construction of oligosilvlated organic scaffolds, but their limited availability has largely prevented such developments in the past. As two of very few examples, C can readily be permethylated and permethoxylated;  $^{68}$  D enters into a stereo- and regioselective  $[2\sigma + 2\sigma + 2\pi]$ cycloaddition with quadricyclane to give a corresponding norbornene derivative, which is a useful monomer for the synthesis of membrane polymers with high gas permeability. It is important to note in this context that the reactivities of a number of silvlated olefins increase in the order  $Cl_3Si(H)C=CH_2 < trans-Cl_3Si(H)C=C(H)SiCl_3 < D$  and decrease once electron-withdrawing chlorine atoms are replaced by electron-donating methyl groups. Upon reaction with cyclopentadiene, D forms exo- and endo-norbornenes, albeit only in a dynamic equilibrium with the starting materials.<sup>61</sup> and cyclopentadiene provide 2,3-Alkyne C bis(trichlorosilyl)norbornadiene-2,5 in yields of 83%.73 To push the synthetic utility of C to its limits, we considered the preparation of 1,2-bis(trichlorosilyl)benzenes for the following reasons: (a) Already 1,2-bis(trimethylsilyl)benzenes are not trivial to make, mainly due to steric congestion.<sup>35</sup> (b) The only

published synthesis of 1,2-bis(trichlorosilyl)benzene starts from 1,2-dichlorobenzene and HSiCl<sub>3</sub> and requires irradiation of the reaction mixture with  $\gamma$  rays at temperatures of 300 °C.<sup>74</sup> An exploratory NMR experiment was conducted with C and an approximate twofold excess of 2,3-dimethyl-1,3-butadiene in CD<sub>2</sub>Cl<sub>2</sub>. After heating to 50 °C for 3 d in a flame-sealed tube, NMR spectroscopy and GC/MS confirmed the quantitative consumption of C and the concomitant formation of 1,2bis(trichlorosilyl)-4,5-dimethylcyclohexa-1,4-diene F as the exclusive product (Scheme 6). Repeating the synthesis of F on a preparative scale with subsequent oxidation using 2,3dichloro-5,6-dicyano-1,4-benzoquinone (DDQ) at room temperature resulted in the quantitative conversion to the 1,2disilylbenzene derivative E1 (80% yield with respect to C; for more information see the SI). In this way we achieved the synthesis of **E1** in an overall yield of 52%.<sup>75</sup> Treatment of 1,2disilylbenzene E1 with 6 eq of MeOH in the presence of NMe<sub>2</sub>Et resulted in the formation of the permethoxylated derivative E1OMe (62% yield). To examine the scope of the Diels-Alder reactions of C, also 2,3,4,5-tetraphenyl-2,4cyclopentadien-1-one was used as diene: Heating a CH<sub>2</sub>Cl<sub>2</sub> solution of both compounds at 180 °C for 4 d in a sealed glass ampoule furnished E2 as the only reaction product (83 % vield; Scheme 6). NMR spectroscopic monitoring of the reaction progress showed no resonances assignable to a cyclohexadiene intermediate. Thus, the electrocyclic reaction between C and the ketone appears to be rate limiting, while CO liberation with formation of the aromatic system occurs instantaneously under the conditions applied. Importantly, unwanted desilvlation reactions are not an issue, in spite of the high temperatures required for the cycloaddition reactions and the pronounced steric repulsion between the two SiCl<sub>3</sub> substituents in E1 and E2.

Scheme 6. Synthesis of cyclohexa-1,4-diene F from C and 2,3-dimethyl-1,3-butadiene; subsequent oxidation of F with DDQ to furnish the benzene derivative E1. Synthesis of the benzene derivative E2 from C and 2,3,4,5-tetraphenyl-2,4-cyclopentadien-1-one.



(i) CH<sub>2</sub>Cl<sub>2</sub>, 50°C, 3 d, sealed glass ampoule; (ii) CH<sub>2</sub>Cl<sub>2</sub>, room temperature, 12 h; (iii) CH<sub>2</sub>Cl<sub>2</sub>, MeOH/NMe<sub>2</sub>Et (6 eq), 0 °C to room temperature, 1 h; (iv) CH<sub>2</sub>Cl<sub>2</sub>, 180 °C, 4 d, sealed glass ampoule

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### Characterization of the New Organotrichlorosilanes.

*NMR Spectroscopy.* Plots of the <sup>1</sup>H, <sup>13</sup>C{<sup>1</sup>H}, and <sup>29</sup>Si NMR spectra of all organosilanes covered in this publication, together with a discussion of key NMR features, are provided in the SI. Whenever literature data are available, our results are in full agreement with the previously reported chemical shift values.

X-rav Crystallography and Corresponding Quantum-Chemical Calculations. Crystals of  $[nBu_4N][A]$  and  $[nBu_4N]_2[\mathbf{B}]$  suitable for X-ray analysis were grown from  $CH_2Cl_2$  (Figure 3a,b).<sup>76</sup> The monoanion  $[A]^-$  possesses a  $C_3$ axis,  $[\mathbf{B}]^{2-}$  has no symmetry element. Both compounds contain essentially planar carbanion centers (bond-angle sums =  $358.5^{\circ}-359.9^{\circ}$ ). The two halves of  $[\mathbf{B}]^{2-}$  are mutually orthogonal, thereby minimizing the electrostatic repulsion between the vicinal, carbon-based lone-pair electrons (dihedral angle  $Si(1)C(1)Si(2)//Si(3)C(2)Si(4) = 85.85(6)^{\circ}$ . Nevertheless, the C(1)–C(2) bond is elongated from 1.47 Å, the expected value for a single bond between sp<sup>2</sup>-hybridized carbon atoms,<sup>77</sup> to 1.532(5) Å, a value typically observed for single bonds between sp<sup>3</sup>-hybridized carbon atoms. The C-Si bond length of  $[A]^{-}$  amounts to 1.768(1) Å and the corresponding bonds of  $[\mathbf{B}]^{2-}$  are even slightly shorter (1.744(4) Å - 1.764(4) Å).



Figure 3. Molecular structures of (a)  $[nBu_4N][\mathbf{A}]$ , (b)  $[nBu_4N]_2[\mathbf{B}]$ , (c) **E1**, and (d) **E2** in the solid state;  $[nBu_4N]^+$  ions and H atoms omitted for clarity.

In comparison, the neutral olefin **B** features C–Si bond lengths in the range 1.910(3) Å - 1.917(3) Å.<sup>78</sup> The significantly smaller values found for  $[A]^-$  and  $[B]^{2-}$  are partly due to Coulomb attraction between the anionic carbon atoms and the positively polarized Si atoms, but also symptomatic of partial C=Si double-bond character as a result of  $\pi$  donation from the carbanion lone pairs into energetically low-lying substituent group orbitals (cf. the  $\alpha$  effect; a structural comparison of  $[B]^{2-}$ with its SiMe<sub>3</sub>-substituted congener is provided in the SI).<sup>79</sup> Further insight into the electronic structures of  $[\mathbf{B}]^{2-}$  and  $\mathbf{B}$  was gained from quantum-chemical calculations. First, we note a pleasingly good agreement between the computed and crystallographically determined geometric parameters of both compounds (Table 1).

Table 1. Selected structural parameters of compound	s B,
[B'], and [B] <sup>2-</sup> . The final calculated geometries were	ob-
tained at the PBE0-D3(BJ)(CPCM(CH <sub>2</sub> Cl <sub>2</sub> ))/ma-d	lef2-
TZVP level of theory. <sup>80–85</sup>	

	C(1)–C(2) [Å]		C–Si (av) [Å]		Si(1)C(1)Si(2)//Si(3 )C(2)Si(4) [°]	
com- pound	X-ray	calcd	X-ray	calcd	X-ray	calcd
В	1.368(4)	1.355	1.914	1.905	28.1(2)	27.8
[B•] <sup>-</sup>	-/-	1.438	-/-	1.824	_/_	44.9
$[B]^{2-}$	1.532(5)	1.502	1.753	1.757	85.85(6)	83.4

Natural Bonding Orbital (NBO)<sup>86</sup> analyses and Wiberg bond indices (WBI)<sup>87</sup> reveal a well-defined C=C double bond for **B** (WBI = 1.90) and a C–C single bond for [**B**]<sup>2–</sup> (WBI = 1.00) with two equally occupied (occ = 1.61) p-type electron lone pairs located at the carbon atoms. The lowered occupation of the lone pairs of [**B**]<sup>2–</sup>, a reduced p character of the hybrid orbital at silicon (Si: sp<sup>1.45</sup>, C: sp<sup>2.13</sup>), and the Natural Population Analysis (NPA)<sup>86</sup> charges (12×Cl = -4.77 e, 4×Si = +5.80 e, 2×C = -3.02 e) indicate efficient delocalization of electron density toward the SiCl<sub>3</sub> groups *via* C–Si  $\pi$  interactions (cf. the  $\alpha$  effect; Figure 1). This charge delocalization likely contributes to the stability of [*n*Bu<sub>4</sub>N]<sub>2</sub>[**B**], which shows no tendency for polymerization despite the presence of formally nucleophilic carbanions and electrophilic SiCl<sub>3</sub> moieties in the same molecule (similar arguments hold for [*n*Bu<sub>4</sub>N][**A**]).

For E-type compounds, two possibilities exist to reduce unfavorable interactions between the adjacent SiCl<sub>3</sub> groups: The molecule could widen the bond angles Si(1)-C(1)-C(2) and Si(2)-C(2)-C(1) and/or bend both substituents in opposite directions out of the benzene plane. In the solid-state structure of E1 (Figure 3c), the Si-C-C bond angles are expanded to 127.6(1)° and 128.5(1)°, while the Si(1)-C(1)-C(2)-Si(2) torsion remains negligible  $(-1.1(2)^\circ)$ . Bond-angle expansion is not an option for E2 (Figure 3d), because the SiCl<sub>3</sub> groups would inevitably collide with the ortho-phenyl rings. Thus,  $Si(1)-C(1)-C(2) = 121.5(1)^{\circ}$  and  $Si(2)-C(2)-C(1) = 122.7(1)^{\circ}$ are still close to 120°, while the Si-C-C-Si torsion angle assumes an appreciable value of  $46.6(2)^\circ$ . Similar features as in the cases of E1 and E2 are evident in the solid-state structures of 1,2-bis(trimethylsilyl)-4,5-dichlorobenzene<sup>35</sup> and hexakis(trimethylsilyl)benzene<sup>88</sup>, respectively (cf. the SI for more details).

Redox Properties of **B** and Corresponding Quantum-Chemical Calculations. Our syntheses of the radical species  $[nBu_4N][\mathbf{B}']$  and the dianion salt  $[nBu_4N]_2[\mathbf{B}]$  prove that **B** is capable of accepting not only one but even two electrons without decomposition. Accordingly, the cyclic voltammogram (CV) of **B** in CH<sub>2</sub>Cl<sub>2</sub> with  $[nBu_4N][B(C_6F_5)_4]$  as supporting electrolyte revealed two reversible redox transitions at half wave potentials of  $E_{1/2} = -0.73$  V and -0.98 V (vs. FcH/FcH<sup>+</sup>).<sup>89</sup> We finally note that **B** is not inert toward  $[nBu_4N][PF_6]$  in THF or CH<sub>2</sub>Cl<sub>2</sub>, but rather abstracts F<sup>-</sup> ions from the commonly used supporting electrolyte, which underscores a strong Lewis acidity of the alkene (cf. the SI for more details).

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The neutral compound **B** and its doubly reduced form  $[nBu_4N]_2[\mathbf{B}]$  are colorless in solution and the solid state. Solutions of the monoradical  $[nBu_4N][\mathbf{B}^*]$  in CH<sub>2</sub>Cl<sub>2</sub> show a deep blue color and a concomitant broad absorption band in the UV/vis spectrum ( $\lambda_{max} = 650$  nm). For comparison, the methylated monoanion radical  $[(Me_3Si)_2C-C(SiMe_3)_2]^*$  gives a dark green solution (THF;  $\lambda_{max} = 697$  nm).<sup>90</sup>

The colors of the chlorinated vs. methylated species likely depend on electronic substituent effects and/or the torsion about the central C-C bond. To evaluate the relative weights of both influence factors, we performed quantum-chemical calculations on the neutral olefins B and  $(Me_3Si)_2C=C(SiMe_3)_2$ , because here, contrary to the cases of the corresponding reduced forms, ion pairing does not have to be taken into account as a third important parameter. We come to the conclusions that twisting of the molecular scaffolds absorption influences the bands of B and  $(Me_3Si)_2C=C(SiMe_3)_2$  to similar extents such that the difference between their calculated  $\lambda_{max}^{c}$  values is largely independent of the C-C-torsion angle. At any given torsion angle, differences in the absorption maxima of both olefins result from electronic substituent effects, such as the different  $\pi$ -acceptor strengths of SiCl<sub>3</sub> and SiMe<sub>3</sub> groups (cf. the SI for more information).

With a C–C bond length of 1.438 Å and a dihedral angle of 44.9°, the calculated key structural parameters of the monoradical anion  $[\mathbf{B}^*]^-$  are intermediate between those of **B** and  $[\mathbf{B}]^{2-}$  (Table 1). The progressively more pronounced twist helps to avoid an unfavorable orbital overlap in the course of the stepwise population of the anti-bonding  $\pi^*$  molecular orbital (LUMO) of **B** (Figure 4).



Figure 4. Selected Kohn-Sham molecular orbitals and their energy eigenvalues [eV] of compounds **B**,  $[\mathbf{B}^*]^-$  and  $[\mathbf{B}]^{2-}$  at the PBE0-D3(BJ)(CPCM(CH<sub>2</sub>Cl<sub>2</sub>))/ma-def2-TZVP level of theory. Isosurface value = 0.05 e·bohr<sup>-3</sup>.

TD-DFT calculations show that the intense blue color of  $[\mathbf{B}^{\bullet}]^{-}$  in solution arises from a  $\pi \to \pi^{*}$  transition into the singly occupied molecular orbital of  $[\mathbf{B}^{\bullet}]^{-}$ .

EPR spectra were recorded at room temperature on solutions of  $[nBu_4N][B']$  in CH<sub>2</sub>Cl<sub>2</sub> (0.75 mM). The radical gives rise to a multi-line signal with partly overlapping <sup>35/37</sup>Cl couplings and obscured <sup>29</sup>Si coupling. A simulation of the experimentally obtained spectrum with hyperfine coupling constants of  $a(^{29}Si) = 4.4$  G and  $a(^{35}Cl) = 1.27$  G gave an excellent match (Figure 5). Moreover, the values obtained are in good agreement with calculated coupling constants obtained at the B3LYP(CPCM(CH<sub>2</sub>Cl<sub>2</sub>))/IGLO-III//PBE0-

D3(BJ)(CPCM(CH<sub>2</sub>Cl<sub>2</sub>))/ma-def2-TZVP<sup>86,91</sup> level of theory  $(a(^{29}Si) = -3.3 \text{ G} \text{ and } a(^{35}Cl) = 1.29 \text{ G}; \text{ cf. the SI for more information}). For comparison, the SiMe<sub>3</sub>-substituted radical [(Me<sub>3</sub>Si)<sub>2</sub>C-C(SiMe<sub>3</sub>)<sub>2</sub>]<sup>-</sup> is characterized by an <math>a(^{29}Si)$  value of 4.65 G.<sup>92</sup> The significant spin density  $\rho_s$  on each Si atom of [*n*Bu<sub>4</sub>N][**B**<sup>+</sup>] ( $\rho_s(Si) = 8\%$ ,  $\rho_{s,tot}(4Si) = 32\%$ ;  $\rho_s(C) = 30\%$ ,  $\rho_{s,tot}(2C) = 60\%$ ) indicates a delocalization of the odd electron over all four C–Si bonds. The  $a(^{29}Si)$  value thus seems to be governed mainly by electronic substituent effects, which influence the C–Si bonding interactions.<sup>93</sup>



Figure 5. Optimized EPR spectrum of  $[nBu_4N][\mathbf{B}^*]$  (blue; 0.75 mM in CH<sub>2</sub>Cl<sub>2</sub>, room temperature); fit results: g value = 2.0026, a(<sup>29</sup>Si) = 4.4 G and a(<sup>35</sup>Cl) = 1.27 G, line width(G) = 0.118 G and line width(L) = 0.188 G.

### Mechanistic Considerations.

Our mechanistic proposals are based on the view that the chloride-induced disproportionation of  $Si_2Cl_6$  generates  $[SiCl_3]^-$  ions as the primary reactive species (Scheme 1). The  $[SiCl_3]^-$  intermediate can principally react further in three different ways: (1) A redox reaction may occur during which a single electron is transferred from the anion to the organic substrate R–Cl. (2)  $[SiCl_3]^-$  may dissociate to liberate  $[SiCl_2]$ , which can subsequently insert into the R–Cl bond. (3) If  $[SiCl_3]^-$  reacts as a nucleophile, it could attack either at the carbon atoms or at the chlorine atoms with concomitant formation of  $SiCl_4$  and  $[R]^-$ . The carbanion would subsequently

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have to bite back into  $SiCl_4$  (or  $Si_2Cl_6$ ) to establish a C-SiCl\_3 bond.<sup>46</sup>

*Reaction of*  $[SiCl_3]^-$  *with*  $CCl_4$ . With regard to the reaction of Si<sub>2</sub>Cl<sub>6</sub>/[ $nBu_4N$ ]Cl with CH<sub>2</sub>Cl<sub>2</sub>, Kroke et al. suggested a sequential nucleophilic substitution reaction at the carbon atom (but did not exclude the possibility of a dichlorosilylene pathway). The resulting H<sub>2</sub>C(SiCl<sub>3</sub>)<sub>2</sub> undergoes *in situ* deprotonation by a third molecule of  $[SiCl_3]^-$  to furnish  $[HC(SiCl_3)_2]^-$ . This ionic intermediate subsequently attacks  $SiCl_4$  (or residual Si<sub>2</sub>Cl<sub>6</sub>) and forms HC(SiCl<sub>3</sub>)<sub>3</sub>. A second deprotonation step finally produces  $[nBu_4N][A]$  (Scheme 7 top).<sup>63</sup> The reaction of Si<sub>2</sub>Cl<sub>6</sub>/ $[nBu_4N]$ Cl with CCl<sub>4</sub> in CH<sub>2</sub>Cl<sub>2</sub> proceeds so fast that the detection of intermediates by *in situ* NMR monitoring becomes impossible. The conversion is also highly selective, and we did not observe any side products (only the byproduct SiCl<sub>4</sub>) that could shed light on mechanistic details.

Scheme 7. Proposed reaction mechanisms for the formation of  $[nBu_4N][A]$  from  $[SiCl_3]^-$  and  $CH_2Cl_2$  (Ref[63]) or  $CCl_4$  (this work, top). Comparison of the transition states of the carbophilic vs. halophilic attack of  $[SiCl_3]^-$  on  $CCl_4$  (bottom).

Carbophilic attack of [SiCl<sub>3</sub>]<sup>-</sup> on CH<sub>2</sub>Cl<sub>2</sub>



Halophilic attack of [SiCl<sub>3</sub>]<sup>-</sup> on CCl<sub>4</sub>



Cation =  $[nBu_4N]^+$  omitted for clarity. Calculated transition states for the carbophilic (left) and halophilic (right) attack of  $[SiCl_3]^-$  on CCl<sub>4</sub> at the B2-PLYP-D3(BJ,ATM)+COSMO-

# $RS(CH_2Cl_2)/def2-QZVP//PBE0-D3(BJ)(COSMO(CH_2Cl_2))/def2-TZVPD$ level of theory. $^{81-84,94-98}$

Yet, for the following reasons our current working hypothesis assumes an initial nucleophilic attack of [SiCl<sub>3</sub>] on one of the Cl atoms of  $CCl_4$ , followed by a rebound reaction of the thus generated  $[CCl_3]^-$  ion:<sup>46,99,100</sup> (1) The carbon center of  $CCl_4$  is sterically more shielded than that of  $CH_2Cl_2$ . (2) [CCl<sub>3</sub>]<sup>-</sup> ions are good leaving groups compared to corresponding [H<sub>2</sub>CCl]<sup>-</sup> ions, as evidenced by the haloform reaction<sup>101</sup> and the fact that Me<sub>3</sub>SiCCl<sub>3</sub> is readily desilvlated with  $[nBu_4N]F$ , whereas Me<sub>3</sub>SiCH<sub>2</sub>Cl is not.<sup>102</sup> (3) Within the series of chloromethanes  $CCl_nH_{4-n}$  (n = 1-4), the NBO charges at the Cl atoms continuously become less negative as n increases; for n > 2 the Cl sites are even positivated.<sup>103</sup> CCl<sub>4</sub> was recognized as a typical halogen-bond donor due to positive surface potentials of up to 17 kcal mol<sup>-1</sup> at the end regions of the Cl atoms  $(\sigma$ -holes).<sup>104,105</sup> (4) In neat CCl<sub>4</sub>, the Si<sub>2</sub>Cl<sub>6</sub>/[*n*Bu<sub>4</sub>N]Cl system forms the  $[CCl_3]^-$  adduct  $[nBu_4N][Cl_3C-SiCl_3-CCl_3]$  (see above). (5) Phosphines are isoelectronic to the [SiCl<sub>3</sub>]<sup>-</sup> ion and nucleophilic displacement on halogen atoms of halocarbons is a central concept of phosphine chemistry (cf. the Appel and Corey-Fuchs reactions).<sup>45,106,107</sup> Moreover, our group recently succeeded in the activation of  $CX_4$  (X = Cl, Br) by the geminal frustrated Lewis pair (Fxyl)<sub>2</sub>B-CH<sub>2</sub>-PtBu<sub>2</sub> to furnish  $(Fxyl)_2B(CX_3)-CH_2-P(X)tBu_2$  (Fxyl = 3,5-(CF\_3)\_2C\_6H\_3).<sup>108</sup> To further substantiate our working hypothesis, we calculated the transition states of the carbophilic ( $\Delta G^{\#} = 40.0 \text{ kcal/mol}$ ) vs. halophilic ( $\Delta G^{\#} = 11.3 \text{ kcal/mol}$ ) attack of [SiCl<sub>3</sub>]<sup>-</sup> on CCl<sub>4</sub> and found the latter to be energetically favorable by 28.7 kcal/mol (cf. Scheme 7, bottom).

In contrast to the mechanism that is likely operative in the formation of [*n*Bu<sub>4</sub>N][A] from Si<sub>2</sub>Cl<sub>6</sub>/[*n*Bu<sub>4</sub>N]Cl and CH<sub>2</sub>Cl<sub>2</sub>, we thus propose the following scenario for CCl<sub>4</sub> as the carbon source (Scheme 7, top):  $[SiCl_3]^-$  abstracts a Cl<sup>+</sup> cation from CCl<sub>4</sub> to form SiCl<sub>4</sub> and [CCl<sub>3</sub>]<sup>-</sup>, which then react further to furnish Cl<sub>3</sub>C-SiCl<sub>3</sub> and Cl<sup>-</sup> (nucleophilic attack of [CCl<sub>3</sub>]<sup>-</sup> on residual Si<sub>2</sub>Cl<sub>6</sub> would provide the same product, together with [SiCl<sub>3</sub>]<sup>-</sup>). If this sequence is repeated twice, we obtain the trisilylmethane  $ClC(SiCl_3)_3$ , which, upon losing a last  $Cl^+$ cation to  $[SiCl_3]^-$ , is transformed to  $[A]^-$ . In line with the required stoichiometry, all steps are catalytic in  $[nBu_4N]Cl$ , apart from the final one, which consumes one equivalent of Cl<sup>-,70</sup> The carbon centers of the neutral intermediates become sterically less and less accessible as the reaction proceeds, while the charge of the carbanionic intermediates becomes more and more delocalized due to the  $\alpha$  effects of an increasing number of SiCl<sub>3</sub> substituents (Figure 1). Even with some excess of CCl<sub>4</sub>, we never observed partially silvlated chloromethanes and therefore conclude that the first Cl-atom substitution is rate determining. For steric reasons, also this observation points toward [SiCl<sub>3</sub>]<sup>-</sup> attack on Cl and not the central C atom

All four involved reaction steps are mechanistically related to each other, which renders the proposed scenario simple and conceptually appealing. Nevertheless, the involvement of [SiCl<sub>2</sub>] cannot be excluded, but the non-donor solvent (CH<sub>2</sub>Cl<sub>2</sub>) and the non-coordinating  $[nBu_4N]^+$  counter ion employed are not expected to promote  $[SiCl_3]^-$  dissociation. By the same token, the putative intermediate  $[nBu_4N][CCl_3]$ should have a longer lifetime than alkali metal carbenoids

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 $M[CCl_3]$  (M<sup>+</sup> = alkali metal cation), because the thermodynamic driving force for MCl elimination with concomitant [CCl<sub>2</sub>] formation is lacking.<sup>102,109,110</sup> We therefore consider not only [SiCl<sub>2</sub>]- but also [CCl<sub>2</sub>]-based pathways less likely than the alternative ionic mechanisms. In view of the proven sensitivity of Cl<sub>3</sub>C–SiCl<sub>3</sub> toward Cl<sup>-</sup> ions (Scheme 4), we finally note that five-coordinate anions such as [Cl<sub>3</sub>C–SiCl<sub>4</sub>]<sup>-</sup> and [Cl<sub>3</sub>C–Cl<sub>3</sub>Si–CCl<sub>3</sub>]<sup>-</sup> not only occur as transient intermediates, but can also serve as [CCl<sub>3</sub>]<sup>-</sup>-transfer reagents (cf. Scheme 4).

Scheme 8: Conceivable elementary reactions underlying the formation of  $[nBu_4N]_2[B]$ .



Note: In the cases of paths  $(2) \rightarrow (7)$  and  $(3) \rightarrow (7)$ , at least one of the substituents R in the starting material and the vinyl-anion intermediate must be Cl; in the cases of paths  $(3) \rightarrow (6)$  and  $(3) \rightarrow (7)$ , at least one of the substituents R in the vinyl-anion intermediate and the products must be SiCl<sub>3</sub>. Residual Si<sub>2</sub>Cl<sub>6</sub> should be capable of taking the role of SiCl<sub>4</sub> as a source of SiCl<sub>3</sub> substituents by releasing [SiCl<sub>3</sub>]<sup>-</sup> in place of Cl<sup>-</sup>; the overall balance would remain the same. Cations =  $[nBu_4N]^+$  omitted for clarity.

*Reactions of [SiCl<sub>3</sub>]<sup>-</sup> with C<sub>2</sub>Cl<sub>6</sub> and C<sub>2</sub>Cl<sub>4</sub>. As mentioned above, treatment of C<sub>2</sub>Cl<sub>6</sub> with 1 eq of Si<sub>2</sub>Cl<sub>6</sub> and catalytic amounts of [<i>n*Bu<sub>4</sub>N]Cl quantitatively generates tetrachloroethene, C<sub>2</sub>Cl<sub>4</sub>. For similar reasons as outlined above, C<sub>2</sub>Cl<sub>6</sub>, the higher homologue of CCl<sub>4</sub>, likely reacts with [SiCl<sub>3</sub>]<sup>-</sup> through initial Cl<sup>+</sup>-cation abstraction. The resulting [C<sub>2</sub>Cl<sub>5</sub>]<sup>-</sup> anion eliminates Cl<sup>-</sup> to furnish C<sub>2</sub>Cl<sub>4</sub>.<sup>37</sup> We have also confirmed that the synthesis of [*n*Bu<sub>4</sub>N]<sub>2</sub>[**B**] can equally well (and more costefficiently) be performed using Si<sub>2</sub>Cl<sub>6</sub>/[*n*Bu<sub>4</sub>N]Cl and C<sub>2</sub>Cl<sub>4</sub> rather than  $C_2Cl_6$ . Any further considerations will thus be focused on  $C_2Cl_4$  as starting material.

It is possible to construct reasonable mechanistic scenarios by combining the limited set of substance classes and elementary reactions outlined in Scheme 8.

Addition-elimination,  $(1) \rightarrow (5)$ : Carbophilic attack of  $[SiCl_3]^-$  on chloroethenes will produce alkyl anions,<sup>111</sup> which eliminate Cl<sup>-</sup> to generate (trichlorosilyl)ethenes. A corresponding sequence has been postulated for the stereospecific reaction of C<sub>2</sub>Cl<sub>4</sub> with sodium *p*-toluenethiolate (NaSTol), resulting in the formation of TolS(Cl)C=CCl<sub>2</sub> and ultimately *trans*-TolS(Cl)C=C(Cl)STol.<sup>112</sup>

*Elimination-addition, (2)*→*(6), or elimination-elimination, (2)*→*(7)*: Halophilic attack of [SiCl<sub>3</sub>]<sup>-</sup> on chloroethenes will produce vinyl anions, which can bite back into SiCl<sub>4</sub> to generate (trichlorosilyl)ethenes. Provided that the vinyl anion bears at least one chlorine substituent, an alternative sequence leads to alkynes *via* release of Cl<sup>-,113</sup> Cl atoms in *trans*-β (highest rates), *cis*-β, or even α positions to the electron lone pair are suitable leaving groups.<sup>114–116</sup> Reaction scenarios related to (2)→(6) and (2)→(7) have been investigated in detail using Li(Cl)C=CCl<sub>2</sub> as the example. At −110 °C, the half-life time of the compound is  $t_{1/2}$  = 70-80 min.<sup>115</sup> In our case, Cl<sup>-</sup> elimination from [*n*Bu<sub>4</sub>N][(Cl)C=CCl<sub>2</sub>] should require longer times, similar to the example of [*n*Bu<sub>4</sub>N][CCl<sub>3</sub>] *vs*. M[CCl<sub>3</sub>] discussed above.

Addition-addition,  $(3) \rightarrow (6)$ , or addition-elimination,  $(3) \rightarrow (7)$ : Carbophilic attack of  $[SiCl_3]^-$  on alkynes formed via path  $(2) \rightarrow (7)$  will again generate intermediate vinyl anions, which can undergo the same follow-up reactions as discussed above. Comparable reactions have been described in the context of frustrated Lewis-pair chemistry. As an example, PPh<sub>3</sub> and B(C<sub>6</sub>F<sub>5</sub>)<sub>3</sub> add to PhC=CH to afford the zwitterionic species Ph(Ph<sub>3</sub>P)C=C(H)(B(C<sub>6</sub>F<sub>5</sub>)<sub>3</sub>).<sup>119</sup> [SiCl<sub>3</sub>]<sup>-</sup> should be a stronger nucleophile than PPh<sub>3</sub> and the Lewis acidic SiCl<sub>4</sub> may take the role of B(C<sub>6</sub>F<sub>5</sub>)<sub>3</sub> in C=C triple-bond activation.

*Elimination-addition,*  $(4) \rightarrow (8)$ : Similar to the cases of chloroethenes,  $[SiCl_3]^-$  can accept Cl<sup>+</sup> cations from chloroethynes to generate acetylides, which will re-attack SiCl<sub>4</sub> to afford (trichlorosilyl)ethynes. As a related example, disilylethynes are readily available upon treatment of R<sub>3</sub>SiCl with a mixture of trichloroethene and *n*-BuLi (3 eq) in THF at -78 °C.<sup>120-122</sup> The reaction proceeds *via* LiCl elimination with intermediate formation of dichloroethyne, which undergoes Cl/Li-exchange to form dilithioacetylide.<sup>123</sup>

One should note that all these elementary steps are competing with each other and that their relative importance can change as the reaction proceeds and the nature of the substituents R changes (i.e. Cl vs. SiCl<sub>3</sub>). For example, an alkyl-anion intermediate (cf. (1) $\rightarrow$ (5)) will become increasingly more stable as Cl atoms are replaced by SiCl<sub>3</sub> groups ( $\alpha$  effect; Figure 1). The following insights provided by the literature and by our own control experiments are helpful to arrive at a more focused picture:

a) The dianion salt  $[nBu_4N]_2[\mathbf{B}]$  also forms cleanly if the Cl<sup>-</sup>-induced disproportionation of Si<sub>2</sub>Cl<sub>6</sub> is carried out in C<sub>2</sub>Cl<sub>4</sub> as the solvent (containing a small volume of CH<sub>2</sub>Cl<sub>2</sub> to dissolve  $[nBu_4N]$ Cl). This indicates that the first step of the reaction cascade is rate determining.

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b) The phosphorus congener of  $[SiCl_3]^-$ , Li[PPh<sub>2</sub>], and C<sub>2</sub>Cl<sub>4</sub> furnish the tetrasubstituted ethene  $(Ph_2P)_2C=C(PPh_2)_2$  at -78 °C, whereas under ambient conditions the ethyne Ph<sub>2</sub>PC=CPPh<sub>2</sub> is obtained.<sup>124</sup> It has been suggested that initial substitution leads to the intermediate Cl<sub>2</sub>C=C(Cl)PPh<sub>2</sub>, which upon warming in the presence of excess Li[PPh<sub>2</sub>] provides Ph<sub>2</sub>PC=CPPh<sub>2</sub>, LiCl, and ClPPh<sub>2</sub> (product of a halophilic attack).

c) The elementary reactions compiled in Scheme 8 lead either to (trichlorosilyl)ethenes or -ethynes. We therefore selected trans-Cl<sub>3</sub>Si(Cl)C=C(Cl)SiCl<sub>3</sub><sup>69</sup> and Cl<sub>3</sub>SiC=CSiCl<sub>3</sub> as archetypal members of both compound classes and treated them with  $Si_2Cl_6/Cl^-$  (3 eq;  $CD_2Cl_2$ ). In both cases, we obtained  $[nBu_4N]_2[\mathbf{B}]$  as the major product. In this respect, the overall behavior is similar to that of the Cl<sub>2</sub>C=CCl<sub>2</sub>/Si<sub>2</sub>Cl<sub>6</sub>/Cl<sup>-</sup> mixture. However, the reaction of trans-Cl<sub>3</sub>Si(Cl)C=C(Cl)SiCl<sub>3</sub> is significantly slower than the reactions of Cl<sub>3</sub>SiC=CSiCl<sub>3</sub> or Cl<sub>2</sub>C=CCl<sub>2</sub> (cf. the SI for more information). in the case Only of trans-Cl<sub>3</sub>Si(Cl)C=C(Cl)SiCl<sub>3</sub>, the <sup>29</sup>Si NMR-spectroscopic monitoring of the reaction mixture revealed significant amounts of cyclohexasilane-chloride diadducts, such as [1.1- $(Cl_3Si)_2Si_6Cl_{10} \cdot 2Cl_3^{2-}$  (cf. Scheme 2). These species are common products of the Si<sub>2</sub>Cl<sub>6</sub>/Cl<sup>-</sup> system if other reaction partners are absent, which underlines the reluctance of trans-Cl<sub>3</sub>Si(Cl)C=C(Cl)SiCl<sub>3</sub> to take part in further transformations under the conditions applied. Moreover, small quantities of  $Cl_3SiC \equiv CSiCl_3$  were detectable in the same sample, thereby indicating that trans-Cl<sub>3</sub>Si(Cl)C=C(Cl)SiCl<sub>3</sub> is slowly dechlorinated to Cl<sub>3</sub>SiC=CSiCl<sub>3</sub> and that the observed formation of  $[nBu_4N]_2[\mathbf{B}]$  may ultimately start from the formed ethyne.

Based on these observations, *trans*-Cl<sub>3</sub>Si(Cl)C=C(Cl)SiCl<sub>3</sub> cannot be excluded as a reaction intermediate, but the major pathways likely proceed *via* ethyne species. It is important to note in this context that the reactivity of ClC=CCl toward Si<sub>2</sub>Cl<sub>6</sub>/Cl<sup>-</sup> is not directly assessable, because this highly unstable ethyne can only be handled in ethereal solvents, which are not compatible with Si<sub>2</sub>Cl<sub>6</sub>.<sup>113</sup>

Before this background, we can combine the limited set of substrate classes and elementary reactions outlined in Scheme 8<sup>111</sup> and arrive at a plausible mechanistic scenario, which straightforwardly accounts for all the reactions and C<sub>2</sub>products discussed so far (Scheme 9): The rate-determining first step likely involves a halophilic attack of [SiCl<sub>3</sub>]<sup>-</sup> on C<sub>2</sub>Cl<sub>4</sub>, followed by Cl<sup>-</sup> elimination to give small local concentrations of ClC=CCl (cf. path (2) $\rightarrow$ (7) in Scheme 8). The highly reactive alkyne is immediately transformed further to afford the more stable disilylalkyne Cl<sub>3</sub>SiC=CSiCl<sub>3</sub> (via path  $(3) \rightarrow (7)$  and/or  $(4) \rightarrow (8)$ ). A carbophilic attack of  $[SiCl_3]^-$  on the electron-poor intermediate Cl<sub>3</sub>SiC=CSiCl<sub>3</sub> leads to the vinyl anion  $[Cl_3SiC=C(SiCl_3)_2]^-$  ( $[G_{open}]^-$ ), which stabilizes itself through intramolecular adduct formation resulting in the SiC<sub>2</sub>-ring compound  $[G_{closed}]^-$  with pentacoordinate Si atom. If  $[SiCl_3]^-$  ions are in sufficient supply, attack on  $[G_{closed}]^-$  induces ring opening with formation of the dianion  $[\mathbf{B}]^{2-}$  (black path). If  $[SiCl_3]^-$  ions are lacking, one  $[G]^-$  anion can transfer an  $[SiCl_3]^-$  fragment to another  $[G]^-$  anion, which is equivalent to a disproportionation reaction and affords equimolar quantities of C and  $[B]^{2-}$  (green path). Since this is precisely the product distribution we observe (together with 1 eq of SiCl<sub>4</sub>)

when we treat olefin **B** with 1 eq of  $[nBu_4N]Cl$  in the absence of CuCl<sub>2</sub>,  $[\mathbf{G}_{closed}]^-$  likely also constitutes the key intermediate in the conversion of **B** to **C**. This assumption is further supported by the fact that the corresponding protonation product, **D**, quantitatively forms upon addition of  $[nBu_4N]Cl$  to **B** in the presence of  $[HMe_3N]Cl$  as a mild proton source (red path)

Scheme 9: Proposed mechanism for the reactions underlying the formation of all  $C_2$ -species covered in this work.



Black path: Formation of  $[\mathbf{B}]^{2-}$  from Si<sub>2</sub>Cl<sub>6</sub>/[*n*Bu<sub>4</sub>N]Cl/C<sub>2</sub>Cl<sub>4</sub> mixtures; green path: formation of **C** through treatment of **B** with [*n*Bu<sub>4</sub>N]Cl; red path: formation of **D** through treatment of **B** with [*n*Bu<sub>4</sub>N]Cl in the presence of [HMe<sub>3</sub>N]Cl; cations = [*n*Bu<sub>4</sub>N]<sup>+</sup> omitted for clarity.

The vinyl anion  $[\mathbf{G}]^-$  is a crucial species in our mechanistic scenario and the crossing point of several reaction paths. Yet, despite many attempts, we have so far not succeeded in its isolation, let alone structural characterization. We therefore investigated the structure and reactivity of  $[\mathbf{G}]^-$  by means of quantum-chemical calculations at B2-PLYP-D3(BJ, ATM)+COSMO-RS(CH<sub>2</sub>Cl<sub>2</sub>)/def2-QZVP//PBE0-

D3(BJ)(COSMO(CH<sub>2</sub>Cl<sub>2</sub>))/def2-TZVPD level of theory.<sup>81-84,94-98</sup> We indeed found two minimum structures, the openchain structure [ $\mathbf{G}_{open}$ ]<sup>-</sup> and the cyclic structure [ $\mathbf{G}_{closed}$ ]<sup>-</sup>, the former being less stable by  $\Delta \mathbf{G} = 4.2$  kcal/mol (Figure 6). Given the low energy barriers of the transition state  $\mathbf{TS}_1$  in both directions, [ $\mathbf{G}_{open}$ ]<sup>-</sup> and [ $\mathbf{G}_{closed}$ ]<sup>-</sup> should be interconvertible at room temperature. In line with that, the lengths of the C=C double bonds in [ $\mathbf{G}_{open}$ ]<sup>-</sup> (1.336 Å) and [ $\mathbf{G}_{closed}$ ]<sup>-</sup> (1.349 Å) are very similar; the C-C-Si bond angle about the carbanion The proposed attack of  $[\text{SiCl}_3]^-$  on  $[\mathbf{G}_{\text{closed}}]^-$  requires only little activation energy ( $\mathbf{TS}_2 = 10.5 \text{ kcal/mol}$ ), even though the electrostatic repulsion of two negative charges has to be overcome. As to be expected from the high yields of  $[\mathbf{B}]^{2^-}$ , its formation is strongly exergonic ( $\Delta G = -27.1 \text{ kcal/mol}$ ).



Figure 6. Relative Gibbs free energy diagram for the formation of  $[B]^{2-}$  from  $[G_{closed}]^-$  at the B2-PLYP-D3(BJ, ATM)+COSMO-RS(CH<sub>2</sub>Cl<sub>2</sub>)/def2-QZVP//PBE0-D3(BJ)(COSMO(CH<sub>2</sub>Cl<sub>2</sub>))/def2-TZVPD level of theory.<sup>81-84,94-98</sup> All energies are given in kcal/mol relative to  $[G_{closed}]^-$ .

Schemes 8 and 9 provide plausible explanations of how the unique vicinal dianion  $[\mathbf{B}]^{2-}$  may form through the Cl<sup>-</sup>induced disproportionation of Si<sub>2</sub>Cl<sub>6</sub> in the presence of C<sub>2</sub>Cl<sub>4</sub>. However, they do not account for all available experimental evidence and the detailed picture is likely more complex:

(a) The reproducible appearance of the blue radical  $[\mathbf{B}']^{-}$  in almost all reaction mixtures indicates that single-electron-transfer (SET) processes are operative in addition to the proposed closed-shell pathways.

(b) The nature of  $[SiCl_3]^-$  as  $C\Gamma$  adduct of  $[SiCl_2]$  (Scheme 1) opens a possibility for silylene-type reactions. For example, [2+1] cycloaddition between the disilylethyne **C** and  $[SiCl_2]$  would lead to a silacyclopropene,<sup>125</sup> which could subsequently engage in a  $C\Gamma$  association/dissociation equilibrium with  $[\mathbf{G}_{closed}]^{-126}$ 

(c) The tetrasilylethene **B** is readily reduced to  $[\mathbf{B}]^{2-}$  by means of Si<sub>2</sub>Cl<sub>6</sub>/Cl<sup>-</sup> in CH<sub>2</sub>Cl<sub>2</sub> and can thus not be ruled out as a potential synthesis intermediate of  $[\mathbf{B}]^{2-}$ .

Fortunately, "all roads lead to Rome" and all the conceivable reaction pathways ultimately join to provide excellent yields of  $[\mathbf{B}]^{2^{-}}$ .

### CONCLUSION

We have developed convenient protocols for the synthesis of multiply SiCl<sub>3</sub>-substituted organic scaffolds, starting from

Cl<sub>2</sub>C=CCl<sub>2</sub>, a stable, non-flammable compound, so cheap that it is widely used in dry cleaning:<sup>127</sup> Upon reaction with the Si<sub>2</sub>Cl<sub>6</sub>/Cl<sup>-</sup> system, Cl<sub>2</sub>C=CCl<sub>2</sub> furnishes the vicinal dianion  $[(Cl_3Si)_2C-C(SiCl_3)_2]^{2-}$  ([**B**]<sup>2-</sup>) in excellent yields. One-step transformations of  $[\mathbf{B}]^{2-}$  lead to the tetrasilylethane  $(Cl_3Si)_2(H)C-C(H)(SiCl_3)_2$ (H<sub>2</sub>**B**), the tetrasilvlethene **(B)**, the  $(Cl_3Si)_2C=C(SiCl_3)_2$ trisilylethene (Cl<sub>3</sub>Si)<sub>2</sub>C=C(H)(SiCl<sub>3</sub>) **(D)**, or the disilvlethyne  $Cl_3SiC \equiv CSiCl_3$  (C). By virtue of their SiCl\_3 groups, all these products are useful building blocks for silicones and silsesquioxanes. Moreover, the unsaturated C=C and C=C bonds of B/D and C offer ample opportunities for further functionalization, e.g., through hydrosilylation or cycloaddition reactions. We have already used the latter, followed by a final aromatization step. to prepare previously unknown 1.2bis(trichlorosilyl)benzenes (E) from C and a selection of butadienes. The potential of E-type compounds as ditopic, chelating Lewis acids or Hiyama-coupling reagents is currently being explored in our laboratories.

The reaction cascade leading to the key product  $[\mathbf{B}]^{2-}$  likely starts with the halophilic attack of [SiCl<sub>3</sub>] on Cl<sub>2</sub>C=CCl<sub>2</sub> and continues with the intermediate formation of C, which is then subject to a carbophilic attack of [SiCl<sub>3</sub>]<sup>-</sup> to give the vinyl anion [(Cl<sub>3</sub>Si)<sub>2</sub>C=CSiCl<sub>3</sub>]<sup>-</sup> ([G]<sup>-</sup>). According to quantumchemical calculations, [G]<sup>-</sup> readily adds a second [SiCl<sub>3</sub>]<sup>-</sup> ion to afford  $[\mathbf{B}]^{2-}$ . The vinyl anion  $[\mathbf{G}]^{-}$  also forms during the synthesis of C via the Cl<sup>-</sup>induced elimination of SiCl<sub>4</sub> from **B**. In the absence of other reaction partners,  $[\mathbf{G}]^-$  disproportionates and thereby furnishes equimolar amounts of C and  $[\mathbf{B}]^{2-}$ . Added CuCl<sub>2</sub> oxidizes  $[\mathbf{B}]^{2-}$  in situ and continuously regenerates the starting material **B**, which substantially improves the yields of C. This last example underscores the benefit gained from our mechanistic insights, even though the full scenario is probably more complex and includes [SiCl<sub>2</sub>] chemistry as well as single-electron-transfer processes (cf. the appearance of the blue radical  $[B']^-$  during the synthesis of  $[\mathbf{B}]^{2-}$ ). Fortunately, most of these pathways are apparently funneling into the same channel such that  $[\mathbf{B}]^{2-}$  is formed with remarkably high selectivity.

### ASSOCIATED CONTENT

**Supporting Information.** Experimental details and characterization data (PDF). This material is available free of charge via the Internet at http://pubs.acs.org.

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### REFERENCES

(1) Holleman, A. F.; Wiberg, N. *Lehrbuch der Anorganischen Chemie*, 102nd ed.; de Gruyter: Berlin, NY, 2007.

(2) Lambert, J. B. The Interaction of Silicon with Positively Charged Carbon. *Tetrahedron* **1990**, *46*, 2677–2689.

(3) Brook, M. A. *Silicon in Organic, Organometallic and Polymer Chemistry*, 1. ed.; John Wiley & Sons: New York, 2000.

(4) Sartori, G.; Ballini, R.; Bigi, F.; Bosica, G.; Maggi, R.; Righi, P. Protection (and Deprotection) of Functional Groups in Organic Synthesis by Heterogeneous Catalysis. *Chem. Rev.* **2004**, *104*, 199–250.

(5) Tamao, K.; Ishida, N.; Tanaka, T.; Kumada, M. Hydrogen Peroxide Oxidation of the Silicon-Carbon Bond in Organoalkoxysilanes. *Organometallics* **1983**, *2*, 1694–1696.

(6) Tamao, K.; Kakui, T.; Akita, M.; Iwahara, T.; Kanatani, R.; Yoshida, J.; Kumada, M. Oxidative Cleavage of Silicon-Carbon Bonds in Organosilicon Fluorides to Alcohols. *Tetrahedron* **1983**, *39*, 983–990.

(7) Tamao, K.; Ishida, N. Silafunctional Compounds in Organic Synthesis. XXVI. Silyl Groups Synthetically Equivalent to the Hydroxy Group. *J. Organomet. Chem.* **1984**, *269*, C37–C39.

(8) Tamao, K.; Kumada, M.; Maeda, K. Silafunctional Compounds in Organic Synthesis. 21. Hydrogen Peroxide Oxidation of Alkenyl(alkoxy)silanes. *Tetrahedron Lett.* **1984**, *25*, 321–324.

(9) Murakami, M.; Suginome, M.; Fujimoto, K.; Nakamura, H.; Andersson, P. G.; Ito, Y. Stereoselective Intramolecular Bis-Silylation of Alkenes Promoted by a Palladium-Isocyanide Catalyst Leading to Polyol Synthesis. *J. Am. Chem. Soc.* **1993**, *115*, 6487– 6498.

(10) Mader, M. M.; Norrby, P. O. Computational Investigation of the Role of Fluoride in Tamao Oxidations. *Chem. Eur. J.* **2002**, *8*, 5043–5048.

(11) Hatanaka, Y.; Hiyama, T. Highly Selective Cross-Coupling Reactions of Organosilicon Compounds Mediated by Fluoride Ion and a Palladium Catalyst. *Synlett* **1991**, *12*, 845–853.

(12) Denmark, S. E.; Sweis, R. F. Cross-Coupling Reactions of Organosilicon Compounds: New Concepts and Recent Advances. *Chem. Pharm. Bull.* **2002**, *50*, 1531–1541.

(13) Hiyama, T. How I Came across the Silicon-Based Cross-Coupling Reaction. J. Organomet. Chem. **2002**, 653, 58–61.

(14) Denmark, S. E.; Sweis, R. F. Design and Implementation of New, Silicon-Based, Cross-Coupling Reactions: Importance of Silicon-Oxygen Bonds. *Acc. Chem. Res.* **2002**, *35*, 835–846.

(15) Hiyama, T.; Shirakawa, E. Organosilicon Compounds. *Top. Curr. Chem.* **2002**, *219*, 61–85.

(16) Denmark, S. E.; Ober, M. H. Organosilicon Reagents: Synthesis and Application to Palladium-Catalyzed Cross-Coupling Reactions. *Aldrichimica Acta* **2003**, *36*, 75–85.

(17) Denmark, S. E.; Regens, C. S. Palladium-Catalyzed Cross-Coupling Reactions of Organosilanols and Their Salts: Practical Alternatives to Boron- and Tin-Based Methods. *Acc. Chem. Res.* **2008**, *41*, 1486–1499.

(18) Van Staden, L. F.; Gravestock, D.; Ager, D. J. New Developments in the Peterson Olefination Reaction. *Chem. Soc. Rev.* **2002**, *31*, 195–200.

(19) Mei, J.; Leung, N. L. C.; Kwok, R. T. K.; Lam, J. W. Y.; Tang, B. Z. Aggregation-Induced Emission: Together We Shine, United We Soar! *Chem. Rev.* **2015**, *115*, 11718–11940.

(20) Weinhold, F.; West, R. The Nature of the Silicon-Oxygen Bond. *Organometallics* **2011**, *30*, 5815–5824.

(21) Baney, R. H.; Itoh, M.; Sakakibara, A.; Suzuki, T. Silsesquioxanes. *Chem. Rev.* **1995**, *95*, 1409–1430.

(22) Loy, D. A.; Shea, K. J. Bridged Polysilsesquioxanes. Highly Porous Hybrid Organic-Inorganic Materials. *Chem. Rev.* **1995**, *95*, 1431–1442.

(23) Corriu, R. J. P.; Leclercq, D. Recent Developments of Molecular Chemistry for Sol-Gel Processes. *Angew. Chem. Int. Ed. Engl.* **1996**, *35*, 1420–1436.

(24) Murugavel, R.; Voigt, A.; Walawalkar, M. G.; Roesky, H. W. Hetero- and Metallasiloxanes Derived from Silanediols, Disilanols, Silanetriols, and Trisilanols. *Chem. Rev.* **1996**, *96*, 2205–2236.

(25) Abbenhuis, H. C. L. Advances in Homogeneous and Heterogeneous Catalysis with Metal-Containing Silsesquioxanes. *Chem. Eur. J.* **2000**, *6*, 25–32.

(26) Cordes, D. B.; Lickiss, P. D.; Rataboul, F. Recent Developments in the Chemistry of Cubic Polyhedral Oligosilsesquioxanes. *Chem. Rev.* **2010**, *110*, 2081–2173.

(27) Corriu, R. J. P.; Granier, M.; Lanneau, G. F. Synthesis and Reactivity of Bis(triethoxysilyl)methane, Tris(triethoxysilyl)methane and Some Derivatives. *J. Organomet. Chem.* **1998**, *562*, 79–88.

(28) Baumgartner, T.; Jaekle, F. *Main Group Strategies towards Functional Hybrid Materials*, 1. Edition.; John Wiley & Sons Inc: Hoboken, NJ, 2018.

(29) Ryan, J. W.; Speier, J. L. The Addition of Silicon Hydrides to Olefinic Double Bonds. Part VI. Addition of Trichlorosilane-D. J. Am. Chem. Soc. **1964**, *86*, 895–898.

(30) Okamoto, M.; Kiya, H.; Yamashita, H.; Suzuki, E. A Novel Catalyst Containing a Platinum Complex in Polyethylene Glycol Medium Supported on Silica Gel for Vapor-Phase Hydrosilylation of Acetylene with Trichlorosilane or Trimethoxysilane. *Chem. Commun.* **2002**, 1634–1635.

(31) Nakajima, Y.; Shimada, S. Hydrosilylation Reaction of Olefins: Recent Advances and Perspectives. *RSC Adv.* 2015, *5*, 20603–20616.

(32) Meister, T. K.; Riener, K.; Gigler, P.; Stohrer, J.; Herrmann, W. A.; Kühn, F. E. Platinum Catalysis Revisited-Unraveling Principles of Catalytic Olefin Hydrosilylation. *ACS Catal.* **2016**, *6*, 1274–1284.

(33) Schmidbaur, H.; Ebenhöch, J. Synthese Und Spektroskopische Charakterisierung Mehrfach Silylierter Ethene. Z. *Naturforsch., B: Chem. Sci.* **1987**, *42*, 1543–1548.

(34) Rosenberg, S. D.; Walburn, J. J.; Ramsden, H. E. Preparation of Some Arylchlorosilanes with Arylmagnesium Chlorides '. J. Org. Chem. **1957**, *22*, 1606–1607.

(35) Lorbach, A.; Reus, C.; Bolte, M.; Lerner, H. W.; Wagner, M. Improved Synthesis of 1,2-Bis(trimethylsilyl)benzenes Using Rieke-Magnesium or the Entrainment Method. *Adv. Synth. Catal.* **2010**, *352*, 3443–3449.

(36) Reus, C.; Liu, N. W.; Bolte, M.; Lerner, H. W.; Wagner, M. Synthesis of Bromo-, Boryl-, and Stannyl-Functionalized 1,2-Bis(trimethylsilyl)benzenes via Diels-Alder or C-H Activation Reactions. *J. Org. Chem.* **2012**, *77*, 3518–3523.

(37) Benkeser, R. A. The Chemistry of Trichlorosilane-Tertiary Amine Combinations. *Acc. Chem. Res.* **1971**, *4*, 94–100.

(38) Benkeser, R. A.; Foley, K. M.; Gaul, J. M.; Li, G. S.; Smith, W. E. Silylation of Acid Chlorides. A New Method of Forming the Carbon-Silicon Bond. *J. Am. Chem. Soc.* **1969**, *91*, 4578–4579.

(39) Benkeser, R. A.; Smith, W. E. A New Method of Forming the Carbon-Silicon Bond. Reductive Silylation of Carbonyl Compounds. J. Am. Chem. Soc. **1969**, *91*, 1556–1557.

(40) Benkeser, R. A.; Foley, K. M.; Gaul, J. M.; Li, G. S. A New and Convenient Method for the Reduction of an Aromatic Carboxyl to a Methyl Group. *J. Am. Chem. Soc.* **1970**, *92*, 3232–3233.

(41) Benkeser, R. A.; Li, G. S.; Mozdzen, E. C. The Reduction of Amides and Silyl Esters with Trichlorosilane-t-Amines. *J. Organomet. Chem.* **1979**, *178*, 21–28.

(42) Pike, R. A. Base-Catalyzed Additions of Trichlorosilane to Hydrocarbon Olefins. *J. Org. Chem.* **1962**, *27*, 2186–2190.

54

55

56

57 58 59

60

(43) Benkeser, R. A.; Dunny, S.; Jones, P. R. Concerning the Amine-Catalyzed Addition of Trichlorosilane to Phenylacetylene. The Structure of the Diadduct. *J. Organomet. Chem.* **1965**, *4*, 338–340.

(44) Benkeser, R. A. The Chemistry of Trichlorosilane in the Presence of Tertiary Amines. *Pure Appl. Chem.* **1969**, *19*, 389–397.

(45) Benkeser, R. A.; Smith, W. E. Trichlorsilane-Tertiary Amine Combinations as Reducing Agents for Polyhalo Compounds. Potential Analogies with Phosphorus Chemistry. *J. Am. Chem. Soc.* **1968**, *90*, 5307–5309.

(46) Benkeser, R. A.; Gaul, J. M.; Smith, W. E. Silylation of Organic Halides. New Method of Forming the Carbon-Silicon Bond. *J. Am. Chem. Soc.* **1969**, *91*, 3666–3667.

(47) Cho, Y. S.; Kang, S. H.; Han, J. S.; Yoo, B. R.; Jung, I. N. Novel Phosphonium Chloride-Catalyzed Dehydrohalogenative Si–C Coupling Reaction of Alkyl Halides with Trichlorosilane. *J. Am. Chem. Soc.* **2001**, *123*, 5584–5585.

(48) Kang, S. H.; Han, J. S.; Yoo, B. R.; Lee, M. E.; Jung, I. N. Phosphonium Chloride-Catalyzed Dehydrochlorinative Coupling Reactions of Alkyl Halides with Hydridochlorosilanes. *Organometallics* **2003**, *22*, 529–534.

(49) Orlandi, M.; Tosi, F.; Bonsignore, M.; Benaglia, M. Metal-Free Reduction of Aromatic and Aliphatic Nitro Compounds to Amines: A HSiCl<sub>3</sub>-Mediated Reaction of Wide General Applicability. *Org. Lett.* **2015**, *17*, 3941–3943.

(50) Karsch, H. H.; Schlüter, P. A.; Bienlein, F.; Herker, M.; Witt, E.; Sladek, A.; Heckel, M. Eine neue Methode zur Darstellung von Silaheterocyclen durch Cycloaddition im System Heterobutadien/HSiCl<sub>3</sub>/NR<sub>3</sub>. Z. Anorg. Allg. Chem. **1998**, 624, 295– 309.

(51) Meyer-Wegner, F.; Nadj, A.; Bolte, M.; Auner, N.; Wagner, M.; Holthausen, M. C.; Lerner, H.-W. The Perchlorinated Silanes Si<sub>2</sub>Cl<sub>6</sub> and Si<sub>3</sub>Cl<sub>8</sub> as Sources of SiCl<sub>2</sub>. *Chem. Eur. J.* **2011**, *17*, 4715–4719.

(52) Schweizer, J. I.; Meyer, L.; Nadj, A.; Diefenbach, M.; Holthausen, M. C. Unraveling the Amine-Induced Disproportionation Reaction of Perchlorinated Silanes-A DFT Study. *Chem. Eur. J.* **2016**, *22*, 14328–14335.

(53) Schweizer, J. I.; Scheibel, M. G.; Diefenbach, M.; Neumeyer, F.; Würtele, C.; Kulminskaya, N.; Linser, R.; Auner, N.; Schneider, S.; Holthausen, M. C. A Disilene Base Adduct with a Dative Si-Si Single Bond. *Angew. Chem. Int. Ed.* **2016**, *55*, 1782– 1786.

(54) Teichmann, J.; Wagner, M. Silicon Chemistry in Zero to Three Dimensions: From Dichlorosilylene to Silafullerane. *Chem. Commun.* **2018**, *54*, 1397–1412.

(55) Tillmann, J.; Meyer, L.; Schweizer, J. I.; Bolte, M.; Lerner, H.-W.; Wagner, M.; Holthausen, M. C. Chloride-Induced Aufbau of Perchlorinated Cyclohexasilanes from Si<sub>2</sub>Cl<sub>6</sub>: A Mechanistic Scenario. *Chem. Eur. J.* **2014**, *20*, 9234–9239.

(56) Teichmann, J.; Bursch, M.; Köstler, B.; Bolte, M.; Lerner, H.-W.; Grimme, S.; Wagner, M. Trapping Experiments on a Trichlorosilanide Anion: A Key Intermediate of Halogenosilane Chemistry. *Inorg. Chem.* **2017**, *56*, 8683–8688.

(57) Tillmann, J.; Moxter, M.; Bolte, M.; Lerner, H.-W.; Wagner, M. Lewis Acidity of Si<sub>6</sub>Cl<sub>12</sub> and Its Role as Convenient SiCl<sub>2</sub> Source. *Inorg. Chem.* **2015**, *54*, 9611–9618.

(58) Tillmann, J.; Wender, J. H.; Bahr, U.; Bolte, M.; Lerner, H.-W.; Holthausen, M. C.; Wagner, M. One-Step Synthesis of a [20]Silafullerane with an Endohedral Chloride Ion. *Angew. Chem. Int. Ed.* 2015, *54*, 5429–5433.

(59) Marciniec, B.; Pietraszuk, C. Synthesis of Unsaturated Organosilicon Compounds Via Alkene Metathesis and Metathesis Polymerization. *Curr. Org. Chem.* **2003**, *7*, 691–735.

(60) Bulgakov, B. A.; Bermeshev, M. V.; Demchuk, D. V.; Lakhtin, V. G.; Kazmin, A. G.; Finkelshtein, E. S. Synthesis of Tricyclononenes and Tricyclononadienes Containing MX<sub>3</sub>-Groups (M=C, Si, Ge; X=Cl, Me). *Tetrahedron* **2012**, *68*, 2166–2171. (61) Bermeshev, M.; Chapala, P.; Lakhtin, V.; Genaev, A.; Filatova, M.; Peregudov, A.; Utegenov, K.; Ustynyuk, N.; Finkelshtein, E. Experimental and Theoretical Study of  $[2\sigma + 2\sigma + 2\pi]$ -Cycloaddition of Quadricyclane and Ethylenes Containing Three Silyl-Groups. *Silicon* **2015**, *7*, 117–126.

(62) Tillmann, J. C. Chlorid-Induzierter Aufbau Perchlorierter Oligosilane Ausgehend von Si<sub>2</sub>Cl<sub>6</sub> oder HSiCl<sub>3</sub>. PhD thesis, University of Frankfurt (Main), Germany, 2015.

(63) Böhme, U.; Gerwig, M.; Gründler, F.; Brendler, E.; Kroke, E. Unexpected Formation and Crystal Structure of the Highly Symmetric Carbanion [C(SiCl<sub>3</sub>)<sub>3</sub>]. *Eur. J. Inorg. Chem.* **2016**, 5028–

5035.
(64) Müller, R.; Reichel, S. Methoxylierung, Methylierung Und Reduktion von Trichlorsilyl-Substituierten Methanen Und Chlormethanen. *Chem. Ber.* 1966, *99*, 793–800.

(65) Fritz, G.; Lauble, S.; Befurt, R.; Peters, K.; Peters, E. M.; von Schnering, H. G. Reaktionen von (Cl<sub>3</sub>Si)<sub>2</sub>CCl<sub>2</sub>, Seiner Si-Methylierten Derivate, von (Cl<sub>3</sub>Si)<sub>2</sub>CHCl, (Cl<sub>3</sub>Si)<sub>2</sub>C(Cl)Me Und Me<sub>2</sub>CCl<sub>2</sub> Mit Silicium (Cu-Kat.). Z. Anorg. Allg. Chem. **1993**, 619, 1494–1511.

(66) Fritz, G.; Beetz, A. G.; Matern, E.; Peters, K.; Peters, E. M.; von Schnering, H. G. Über Den Einfluß Der Reaktionsbedingungen Auf Die Umsetzung von  $(Cl_3Si)_2CCl_2$  Mit Silicium. Die Struktur von 2,2,3,3,5,5,6,6-Octachlor-1,4-Bis(trichlorsilyl)-2,3,5,6-tetrasilabicyclo[2.1.1]hexan Und 1,1,3,4,6,6-Hexakis(trichlorsilyl)hexatetraen. Z. Anorg. Allg. Chem. **1994**, 620, 136–144.

(67) Rüdinger, C.; Beruda, H.; Schmidbaur, H. Synthesis and Molecular Structure of Silylated Ethenes and Acetylenes. *Z. Naturforsch., B: Chem. Sci.* **1994**, *49*, 1348–1360.

(68) Müller, R.; Beyer, H. Umsetzung von Tetrachlorkohlenstoff Mit Silicium. *Chem. Ber.* **1959**, *92*, 1018–1027.

(69) Schmidbaur, H.; Ebenhöch, J.; Müller, G. Synthese, Eigenschaften Und Struktur Einiger Silyl-Ethene. Z. Naturforsch., B: Chem. Sci. **1987**, *42*, 142–146.

(70) Even though our proposed mechanisms ideally requires a 4:1:1 stoichiometry of Si<sub>2</sub>Cl<sub>6</sub>, [*n*Bu<sub>4</sub>N]Cl, and CCl<sub>4</sub> for [*n*Bu<sub>4</sub>N][**A**] (4 Si<sub>2</sub>Cl<sub>6</sub> + [*n*Bu<sub>4</sub>N]Cl + CCl<sub>4</sub>  $\rightarrow$  [*n*Bu<sub>4</sub>N][**A**] + 5 SiCl<sub>4</sub>), and a 5:2:1 stoichiometry of Si<sub>2</sub>Cl<sub>6</sub>, [*n*Bu<sub>4</sub>N]Cl, and C<sub>2</sub>Cl<sub>4</sub> in the case of [*n*Bu<sub>4</sub>N]<sub>2</sub>[**B**] (5 Si<sub>2</sub>Cl<sub>6</sub> + 2 [*n*Bu<sub>4</sub>N]Cl + C<sub>2</sub>Cl<sub>4</sub>  $\rightarrow$  [*n*Bu<sub>4</sub>N]<sub>2</sub>[**B**] + 6 SiCl<sub>4</sub>). We empirically found that a 4:1:1.5 stoichiometry for [*n*Bu<sub>4</sub>N][**A**] and a 4:2:1 stoichiometry for [*n*Bu<sub>4</sub>N]<sub>2</sub>[**B**] is advantageous to suppress side-product formation (mainly oligosilanes).

(71) Müller, R.; Seitz, G. Die Synthese Siliciumorganischer Verbindungen Aus Chloroform. *Chem. Ber.* **1958**, *91*, 22–27.

(72) [HMe<sub>3</sub>N]Cl alone does not react with **B** under the mild conditions applied, likely because the NH···Cl hydrogen bond is so strong that it reduces the nucleophilicity of the Cl<sup>-</sup> ion beyond the critical threshold. A reaction between [HMe<sub>3</sub>N]Cl alone and **B** was observed only at elevated temperatures (T = 80 °C).

(73) Gringolts, M. L.; Bermeshev, M. V.; Makovetsky, K. L.; Finkelshtein, E. S. Effect of Substituents on Addition Polymerization of Norbornene Derivatives with Two Me<sub>3</sub>Si-Groups Using Ni(II)/MAO Catalyst. *Eur. Polym. J.* **2009**, *45*, 2142–2149.

(74) Vainshtein, B. I.; Bogovtseva, L. P. Radiation-chemical Vapor-phase Synthesis of Bis(organochlorosilyl) Derivatives of Aromatic Hydrocarbons. *Zhurnal Obs. Khimii* **1976**, *46*, 852–855.

(75) If the synthesis of **E1** is conducted as a one-pot reaction starting from  $C_2Cl_4$  without isolation of **C** or **F**, we reproducibly observed minor impurities, which are absent if **C** is isolated prior to its use as starting material.

(76) A crystal structure analysis of a polymorph of  $[nBu_4N][A]$  has previously been published by Kroke et al. (Ref[63]). Since the quality of our data is superior to that of the published data, we are using our results for a discussion of the molecular structure.

(77) Whitesell, J. K.; Fox, M. A. *Organic Chemistry*, 3rd ed.; Jones and Bartlett Publishers: London, 2004.

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(78) The crystal structure of **B** has been published (Ref[67]). We have re-determined it using crystals of **B** obtained *via* our new route. Both data sets are of comparable quality. We are referring to our results throughout this publication (cf. the SI for full details).

Further systems for comparison are the trisilylamine (79)N(SiCl<sub>3</sub>)<sub>3</sub> and the tetrasilylhydrazine (Cl<sub>3</sub>Si)<sub>2</sub>N-N(SiCl<sub>3</sub>)<sub>2</sub>, which have been prepared from N2 and SiCl4 in glow discharge or microwave plasmas. Because of the low yields obtained, (Cl<sub>3</sub>Si)<sub>2</sub>N-N(SiCl<sub>3</sub>)<sub>2</sub> could not be isolated or structurally characterized, but quantumchemical calculations predict an orthogonally twisted, C<sub>2</sub>-symmetrical scaffold with trigonal-planar nitrogen atoms: Pflugmacher, A. Dahmen, H. Das Tris-trichlorsilylamin (SiCI<sub>3</sub>)<sub>3</sub>N. Z. Anorg. Allg. Chem. 1957, 290, 184-190; Wannagat, U.; Flindt, R.; Brauer, D. J.; Bürger, H.; Dörrenbach, F. On the Crystalline Products from the Reaction of Silicon Tetrachloride with Nitrogen in a Glow Discharge. Single Crystal X-ray Structure Determination of N(SiCl<sub>3</sub>)<sub>3</sub> and Cl<sub>3</sub>SiN(SiCl<sub>2</sub>)<sub>2</sub>NSiCl<sub>3</sub>. Z. Anorg. Allg. Chem. 1989, 572, 33-46; Schiefenhövel, N.; Himmel, H. J.; Binnewies, M. N2(SiCl3)4 - A Tetrakissilylhydrazine as an Unexpected Product of the Reaction between N2 and SiCl4. Angew. Chem. Int. Ed. 2003, 42, 5956-5957.

(80) Barone, V.; Cossi, M. Quantum Calculation of Molecular Energies and Energy Gradients in Solution by a Conductor Solvent Model. J. Phys. Chem. A **1998**, *102*, 1995–2001.

(81) Adamo, C.; Barone, V. Toward Reliable Density Functional Methods without Adjustable Parameters: The PBE0 Model. *J. Chem. Phys.* **1999**, *110*, 6158–6170.

(82) Becke, A. D.; Johnson, E. R. A Density-Functional Model of the Dispersion Interaction. *J. Chem. Phys.* **2005**, *123*, 154101–1–9.

(83) Grimme, S.; Antony, J.; Ehrlich, S.; Krieg, H. A Consistent and Accurate Ab Initio Parametrization of Density Functional Dispersion Correction (DFT-D) for the 94 Elements H-Pu. *J. Chem. Phys.* **2010**, *132*, 154104–1 – 19.

(84) Grimme, S.; Ehrlich, S.; Goerigk, L. Effect of the Damping Function in Dispersion Corrected Density Functional Theory. *J. Comput. Chem.* **2011**, *32*, 1456–1465.

(85) Zheng, J.; Xu, X.; Truhlar, D. G. Minimally Augmented Karlsruhe Basis Sets. *Theor. Chem. Acc.* **2011**, *128*, 295–305.

(86) Glendening, E. D.; Badenhoop, J. K.; Reed, A. E.; Carpenter, J. E.; Bohmann, J. A.; Morales, C. M.; Landis, C. R.; Weinhold, F. NBO 6.0. NBO 6.0.Theoretical Chemistry Institute, University of Wisconsin: Madison 2013.

(87) Wiberg, K. B. Application of the Pople-Santry-Segal CNDO Method to the Cyclopropylcarbinyl and Cyclobutyl Cation and to Bicyclobutane. *Tetrahedron* **1968**, *24*, 1083–1096.

(88) Sakurai, H.; Ebata, K.; Kabuto, C.; Sekiguchi, A. Synthesis, Properties, and Molecular Structure of Highly Distorted Hexakis(trimethysilyl)benzene. *J. Am. Chem. Soc.* **1990**, *112*, 1799–1803.

(89) For comparison, tetracyanoethene (TCNE) undergoes a reversible first reduction at  $E_{1/2} = -0.27$  V in H<sub>3</sub>CCN solution): Connelly, N. G.; Geiger, W. E. Chemical Redox Agents for Organometallic Chemistry. *Chem. Rev.* **1996**, *96*, 877–910.

(90) Sekiguchi, A.; Nakanishi, T.; Kabuto, C.; Sakurai, H. Isolation and Characterization of 1,2-Dilithio[tetrakis(trimethylsilyl)]ethane. The First Crystal Structure of Nonconjugated 1,2-Dilithioethane. J. Am. Chem. Soc. 1989, 111, 3748–3750.

(91) Becke, A. D. Density-Functional Thermochemistry. III. The Role of Exact Exchange. J. Chem. Phys. **1993**, *98*, 5648–5652.

(92) Sakurai, H.; Nakadaira, Y.; Kira, M.; Tobita, H. Tetrakis(trimethylsilyl)ethylene and Related Compounds, Crowded Olefins. *Tetrahedron Lett.* **1980**, *21*, 3077–3080.

(93) The unusually rapid *cis-trans* isomerization of tetrasilylated ethenes with intermediate formation of two vicinal radical centers also points toward the ability of silyl substituents for stabilizing carbon radicals. In fact, mere heating of (Me<sub>3</sub>Si)<sub>2</sub>C=C(SiMe<sub>3</sub>)<sub>2</sub> at 150 °C (neat or in decalin) produced the persistent radical [(Me<sub>3</sub>Si)<sub>2</sub>C(H)- C(SiMe<sub>3</sub>)<sub>2</sub>], likely through hydrogen-atom abstraction during rotation: Sakurai, H.; Tobita, H.; Kira, M.; Nakadaira, Y. Unusually Rapid cis-trans Isomerization of a Tetrasilylated Ethylene: Generation of Free Radicals During the Rotation. *Angew. Chem. Int. Ed. Engl.* **1980**, *19*, 620–620.

(94) Axilrod, B. M.; Teller, E. Interaction of the van Der Waals Type between Three Atoms. J. Chem. Phys. **1943**, 11, 299–300.

(95) Muto, Y. Force between Nonpolar Molecules. *Proc. Phys. Math. Soc. Japan* **1943**, *17*, 629–631.

(96) Weigend, F.; Ahlrichs, R. Balanced Basis Sets of Split Valence, Triple Zeta Valence and Quadruple Zeta Valence Quality for H to Rn: Design and Assessment of Accuracy. *Phys. Chem. Chem. Phys.* **2005**, *7*, 3297–3305.

(97) Grimme, S. Semiempirical Hybrid Density Functional with Perturbative Second-Order Correlation. *J. Chem. Phys.* **2006**, *124*, 34108–1–15.

(98) Rappoport, D.; Furche, F. Property-Optimized Gaussian Basis Sets for Molecular Response Calculations. *J. Chem. Phys.* **2010**, *133*, 134105–1–11.

(99) Siegel, H.; Hiltbrunner, K.; Seebach, D. <sup>13</sup>C-NMR Spectra of Tribromomethyllithium and 1,1-Dibromoethyllithium. *Angew. Chem. Int. Ed. Engl.* **1979**, *18*, 785–786.

(100) Seebach, D.; Siegel, H.; Gabriel, J.; Hässig, R. Tieftemperatur <sup>13</sup>C-NMR.Spektren von <sup>13</sup>C- Und <sup>6</sup>Li- Markierten Chlor-, Brom- Und Jod-Lithium-Carbenoiden. *Helv. Chim. Acta* **1980**, *63*, 2046–2053.

(101) Vollhardt, K. P. C.; Schore, N. E. *Organische Chemie*; Butenschön, H., Ed.; Wiley-VCH: Weinheim, Germany, 2005.

(102) Fujita, M.; Hiyama, T. Fluoride Ion Catalyzed Aldehyde Addition of Labile  $\alpha$ -or  $\beta$ -Halocarbanion Species Generated from the Corresponding  $\alpha$ - or  $\beta$ -Halo Organosilanes. *J. Am. Chem. Soc.* **1985**, *107*, 4085–4087.

(103) Donald, K. J.; Böhm, M. C.; Lindner, H. J. Analysis of Competing Bonding Parameters. Part 1. The Structure of Halomethanes ( $CH_{4-n}X_n$ , n=1-4, X=F, Cl, Br). J. Mol. Struct. 2004, 710, 1–11.

(104) Wang, P.; Zhao, N.; Tang, Y. Halogen Bonding in the Complexes of CH<sub>3</sub>I and CCl<sub>4</sub> with Oxygen-Containing Halogen-Bond Acceptors. *J. Phys. Chem. A* **2017**, *121*, 5045–5055.

(105) Weak complexes  $L\rightarrow ClCCl_3$  with Lewis bases L such as pyridine or THF have been observed (cf. Ref[104]). It is thus reasonable to expect that the Cl atoms of CCl<sub>4</sub> will also attract an incoming [SiCl<sub>3</sub>]<sup>-</sup> ion: Brinck, T.; Murray, J. S.; Politzer, P. Surface Electrostatic Potentials of Halogenated Methanes as Indicators of Directional Intermolecular Interactions. *Int. J. Quantum Chem.* **1992**, *44*, 57–64.

(106) Corey, E. J.; Fuchs, P. L. A Synthetic Method for Formyl-Ethynyl Conversion. *Tetrahedron Lett.* **1972**, *36*, 3769–3772.

(107) Appel, R. Tertiary Phosphane/Tetrachloromethane, a Versatile Reagent for Chlorination, Dehydration, and P-N Linkage. *Angew. Chem. Int. Ed.* **1975**, *14*, 801–811.

(108) Samigullin, K.; Georg, I.; Bolte, M.; Lerner, H.-W.; Wagner, M. A Highly Reactive Geminal P/B Frustrated Lewis Pair: Expanding the Scope to C-X (X=Cl, Br) Bond Activation. *Chem. Eur. J.* **2016**, *22*, 3478–3484.

(109) Shono, T.; Kashimura, S.; Ishizaki, K.; Ishige, O. A New Electrogenerated Base. Condensation of Chloroform with Aliphatic Aldehydes. *Chem. Lett.* **1983**, 1311–1312.

(110) Shono, T.; Ishifune, M.; Ishige, O.; Uyama, H.; Kashimura, S. Formation of a Reasonably Stabilized Trichloromethyl Anion by the Reaction of Chloroform with Electrogenerated Base, and Its 1,4-Addition to  $\alpha$ , $\beta$ -Unsaturated Carbonyl Compounds. *Tetrahedron Lett.* **1990**, *31*, 7181–7184.

(111) Rappoport, Z. Nucleophilic Vinylic Substitution. A Singleor a Multi-Step Process? *Acc. Chem. Res.* **1981**, *14*, 7–15.

(112) Truce, W. E.; Rossmann, M. G.; Perry, F. M.; Burnett, R. M.; Abraham, D. J. The Stereochemistry of the Reaction of

Tetrachloroethylene with *p*-Toluenethiolate Reagent. *Tetrahedron* **1965**, *21*, 2899–2905.

(113) Grossmann, A. S.; Magauer, T. Trihaloethenes as Versatile Building Blocks for Organic Synthesis. *Org. Biomol. Chem.* **2016**, *14*, 5377–5389.

(114) Köbrich, G.; Flory, K. Zur Existenz von C-Atomen Mit Halogen- Und Alkali- Metall-Substituenten III - Über Metallierte Chloräthylene Und Deren Zerfallsreaktionen. *Tetrahedron Lett.* **1964**, *19*, 1137–1142.

(115) Köbrich, G.; Flory, K. Chlorsubstituierte Vinyllithium-Verbindungen. *Chem. Ber.* **1966**, *99*, 1773–1781.

(116) Nelson, D. J.; Mercer, B. D. An MNDO Study of Structures and Stabilities of Representative 1-Chloro-1-Alkenes and of Their Beryllium Hydride Derivatives. *Tetrahedron* **1988**, *44*, 6287–6294.

(117) Bartsch, R. Ionic Association in Base-Promoted  $\beta$  Elimination Reactions. *Acc. Chem. Res.* **1975**, *8*, 239–245.

(118) Nagaki, A.; Takahashi, Y.; Henseler, A.; Matsuo, C.; Yoshida, J. Flash Chemistry Using Trichlorovinyllithium: Switching the Reaction Pathways by High-Resolution Reaction Time Control. *Chem. Lett.* **2015**, *44*, 214–216.

(119) Dureen, M. A.; Stephan, D. W. Terminal Alkyne Activation by Frustrated and Classical Lewis Acid/Phosphine Pairs. *J. Am. Chem. Soc.* **2009**, *131*, 8396–8397.

(120) Ijadi-Maghsoodi, S.; Pang, Y.; Barton, T. J. Efficient, "One-Pot" Synthesis of Silylene-Acetylene and Disilylene-Acetylene Preceramic Polymers from Trichloroethylene. J. Polym. Sci., Part A Polym. Chem. **1990**, 28, 955–965. (121) Kang, Y. K.; Deria, P.; Carroll, P. J.; Therien, M. J. Synthesis of Water-Soluble Poly (*p*-Phenyleneethynylene) in Neat Water under Aerobic Conditions via Suzuki-Miyaura Polycondensation Using a Diboryethyne Synthon. *Org. Lett.* **2008**, *10*, 1341–1344.

(122) Shynkaruk, O.; Qi, Y.; Cottrell-Callbeck, A.; Delgado, W. T.; McDonald, R.; Ferguson, M. J.; He, G.; Rivard, E. Modular Synthesis of Diarylalkynes and Their Efficient Conversion into Luminescent Tetraarylbutadienes. *Organometallics* **2016**, *35*, 2232–2241.

(123) All our attempts to synthesize the ethyne C from SiCl<sub>4</sub> and Li<sub>2</sub>C<sub>2</sub> or CaC<sub>2</sub> in THF/Et<sub>2</sub>O failed.

(124) Anderson, D. M.; Hitchcock, P. B.; Lappert, M. F. Synthesis, Characterisation, and Crystal Structure of a Tetra(phosphino)ethene [PhCH<sub>2</sub>CH<sub>2</sub>P(Ph)C=]<sub>2</sub>. J. Organomet. Chem. **1989**, 363, C7–C11.

(125) Ishikawa, M.; Naka, A.; Ohshita, J. The Chemistry of Silacyclopropenes. *Asian J. Org. Chem.* **2015**, *4*, 1192–1209.

(126) Damrauer, R.; Crowell, A. J.; Craig, C. F. Electron, Hydride, and Fluoride Affinities of Silicon-Containing Species: Computational Studies. *J. Am. Chem. Soc.* **2003**, *125*, 10759–10766.

(127) Karellas, N. S.; Chen, Q. Real-Time Air Monitoring of Trichloroethylene and Tetrachloroethylene Using Mobile TAGA Mass Spectrometry. J. Environ. Prot. **2013**, *4*, 99–105.

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